



**The Abdus Salam
International Centre for Theoretical Physics**



2132-7

Winter College on Optics and Energy

8 - 19 February 2010

Anti-reflection and light-trapping

D. Bagnall
Southampton University
U.K.

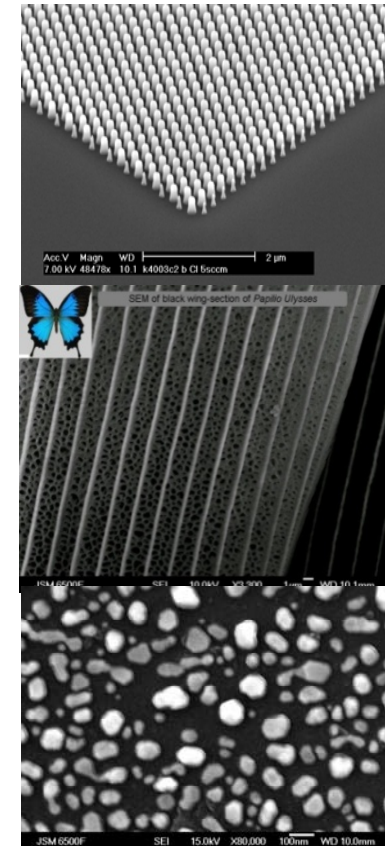
Anti-reflection and light-trapping

Professor Darren Bagnall

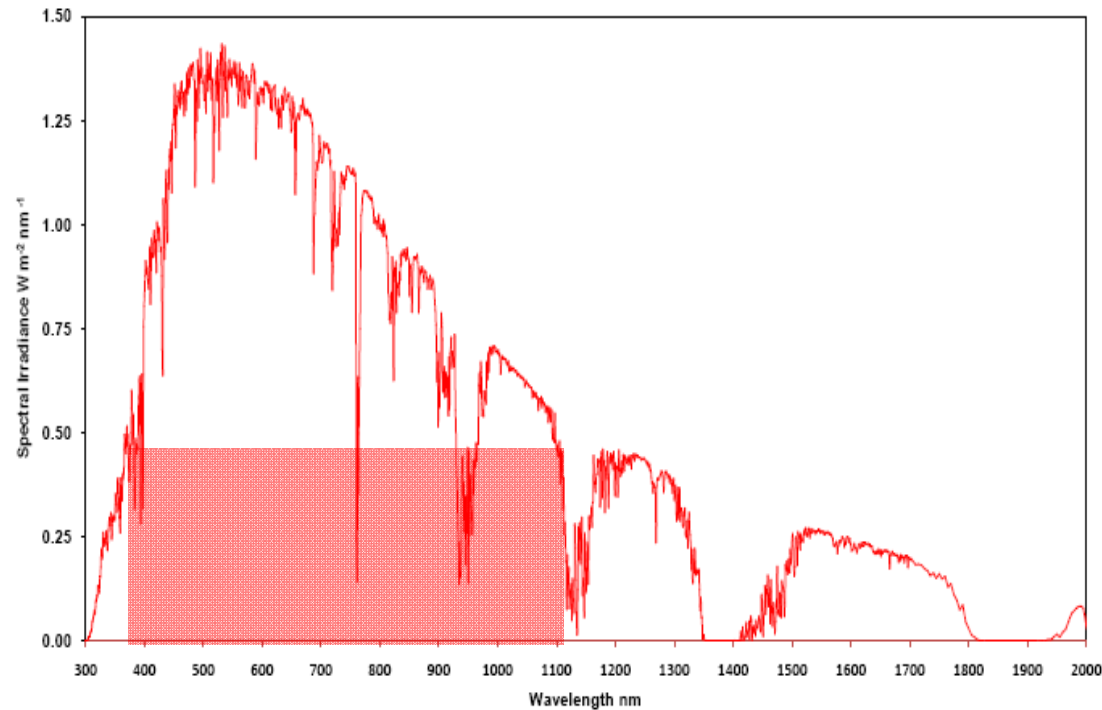
Electronics and Computer Science, Southampton University

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 - photonic

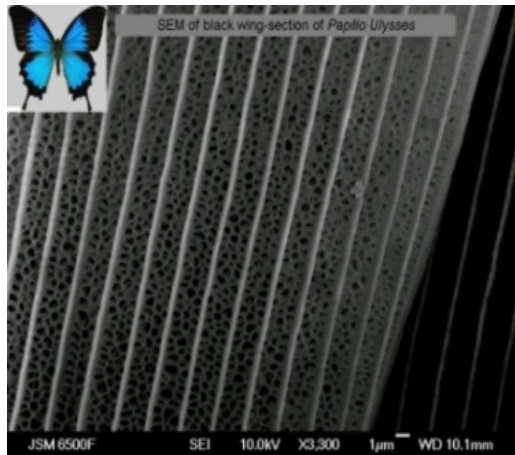


Challenge of Broadband

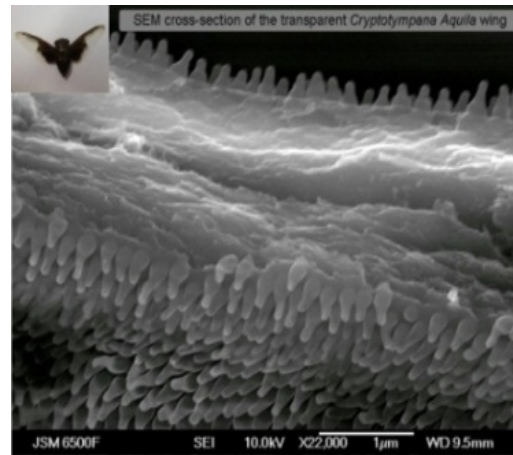


- laser-based photonic technologies can be 99.9% efficient over 100nm spectral range
- applying photonics to photovoltaics requires efficiency for 700nm of bandwidth.
- optimal solutions for AR and LT require spectral irradiance and IQE to be considered and disordered (chirped) designs.

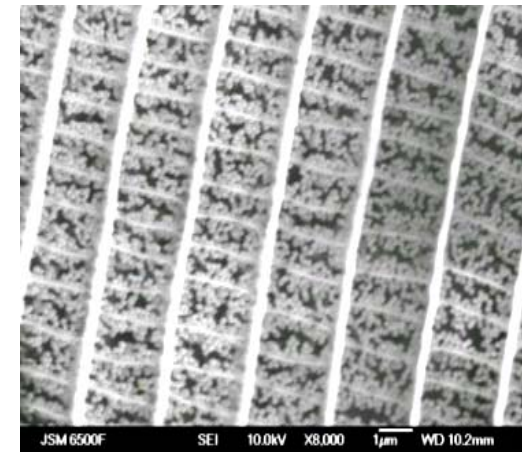
Biomimetics and Plasmonics



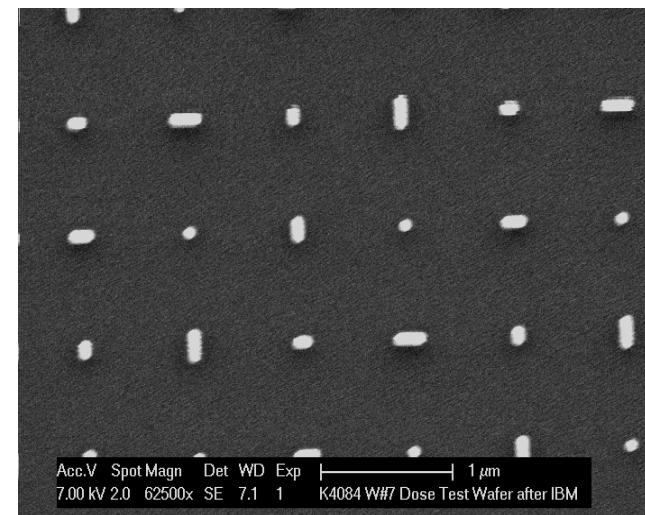
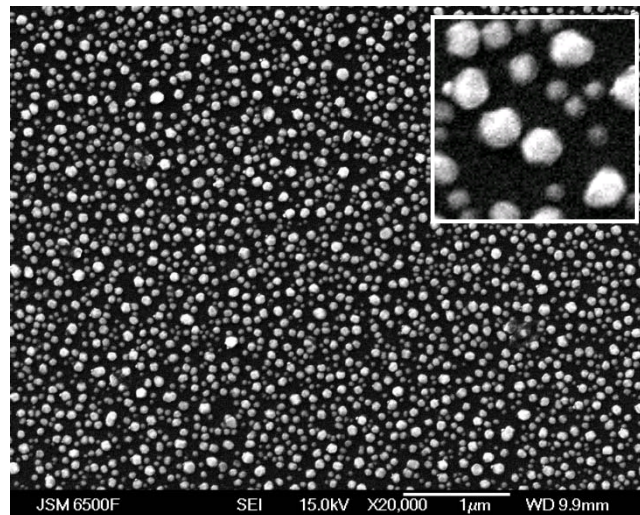
colour



transparent

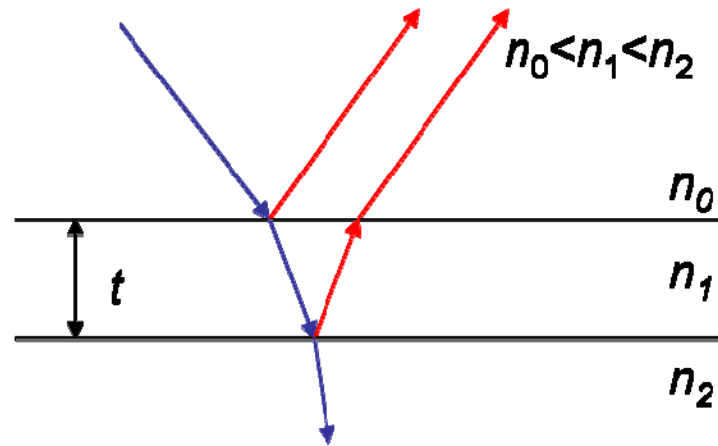


white



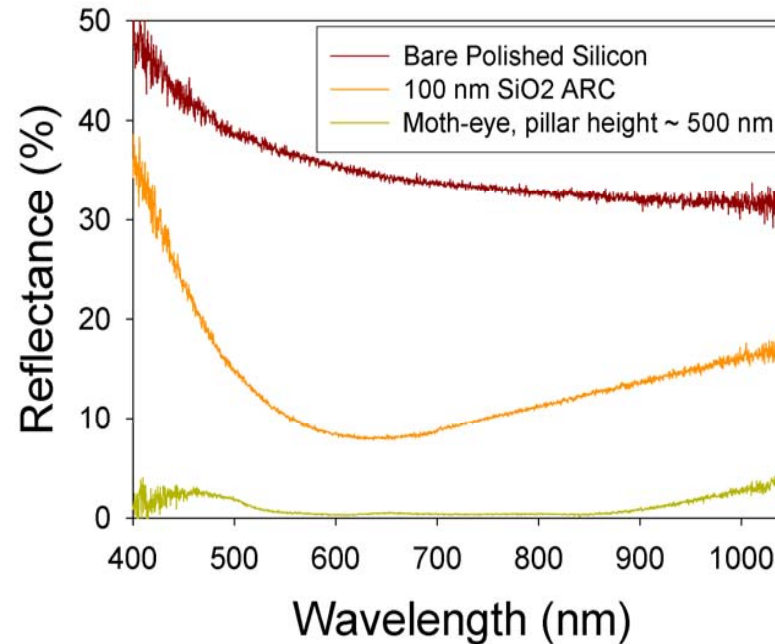
Anti-reflection

Single layer AR coating



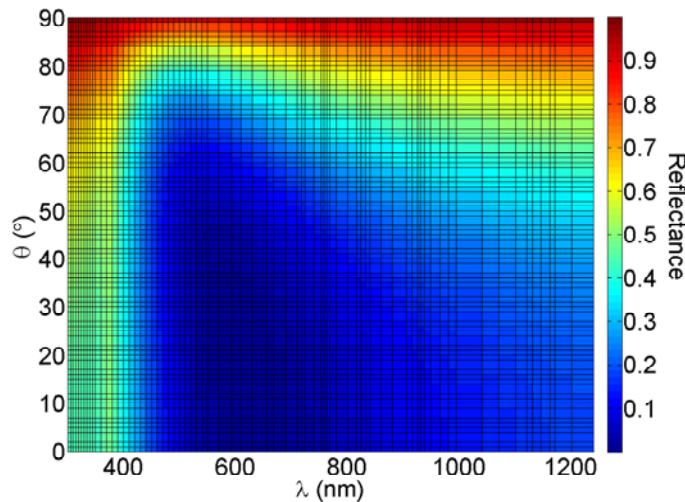
- to reduce reflection a single thin film of quarter wavelength thickness (taking into account refractive index) uses interference to reduce intensity of reflected beam
- about 110nm of SiO_2 is simplest AR coating for Si

Single layer AR coating

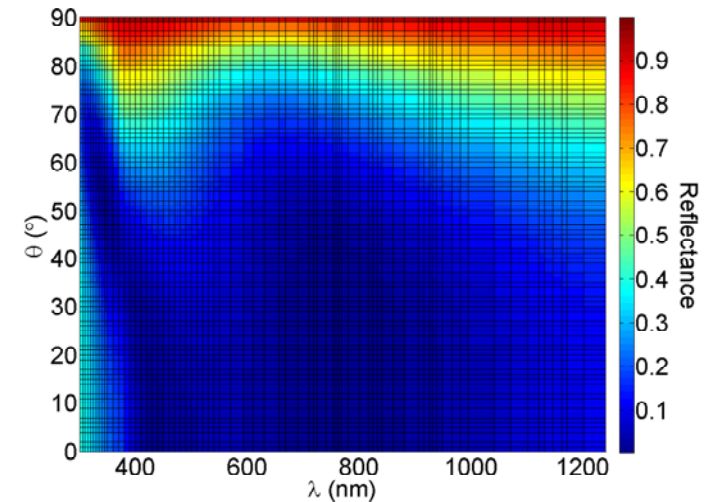


- single layer ARCs are much better than bare surface (roughly half reflection)
- still, around 20% of light is still reflected

Double-layer AR coatings



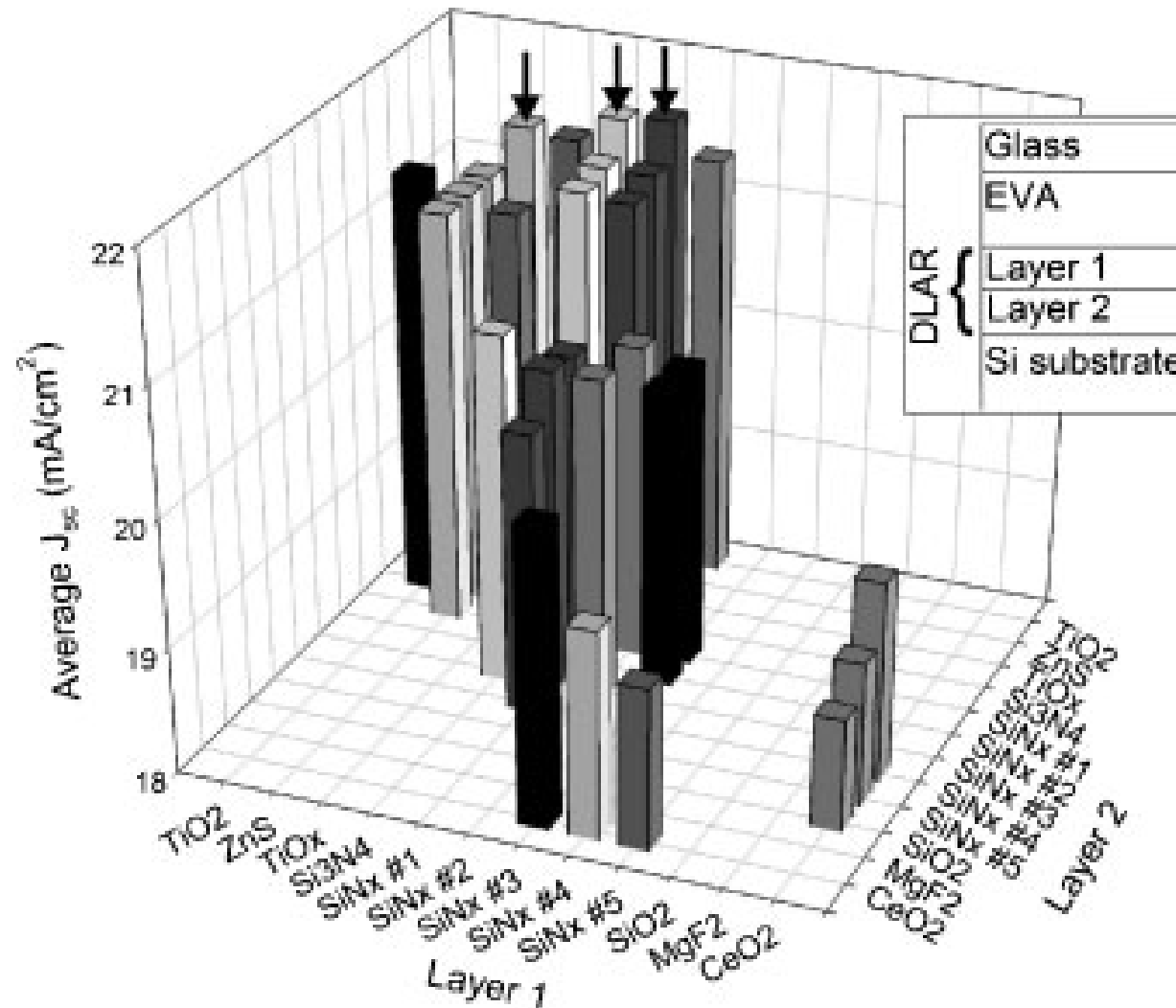
CeO SLAR



ZnS,MgF₂ DLAR

- Double layer coatings can be used to broaden the AR effect and further reduce reflected intensity
- Ultimately there is only a small range of suitable materials (n) that do not absorb.

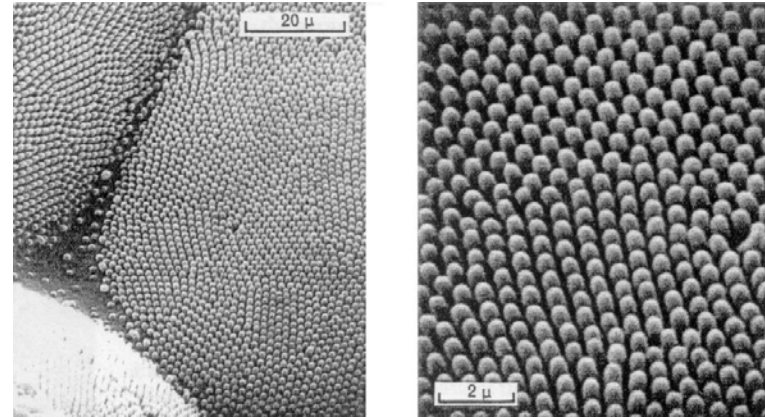
Double-layer AR coatings



[Boden and Bagnall, Prog. Photovolt: Res. Appl. 2009; 17:241-252]

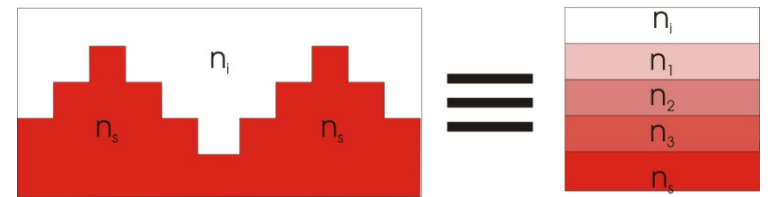
Biomimetic moth-eyes

- **Nanostructured corneal surface of some night moths**
 - Improved eyesight
 - Less visible to predators



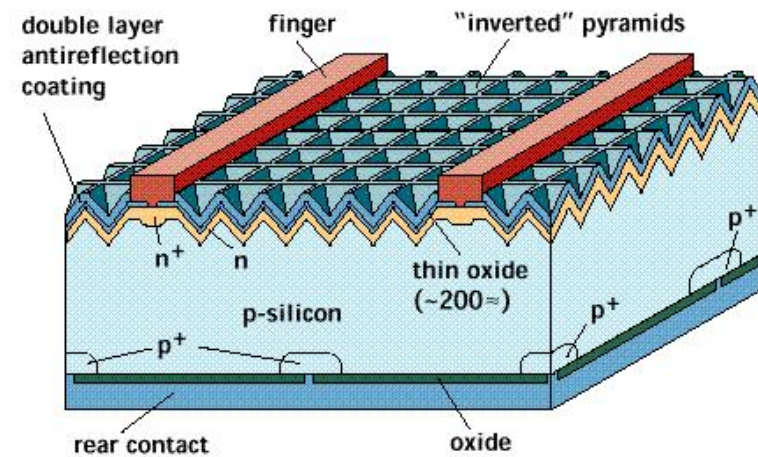
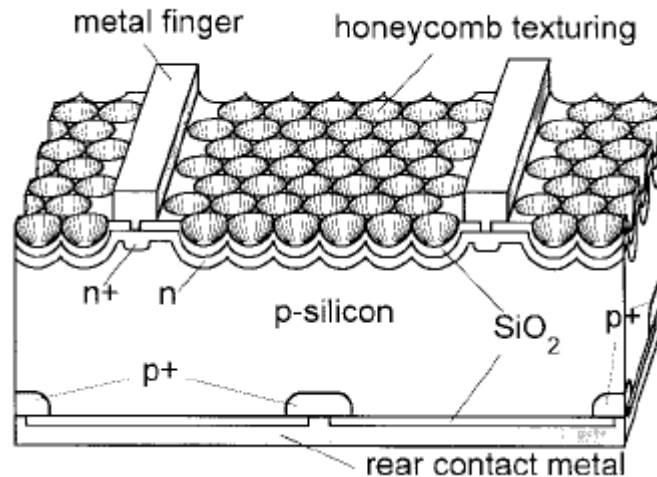
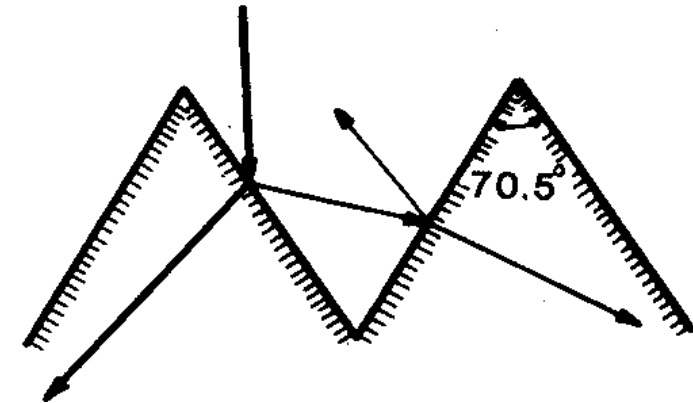
Bernhard, Endeavour vol 26, pp. 79-84, (1967)

- **Arrays of subwavelength features**
- **Gradual change in refractive index from air into substrate**

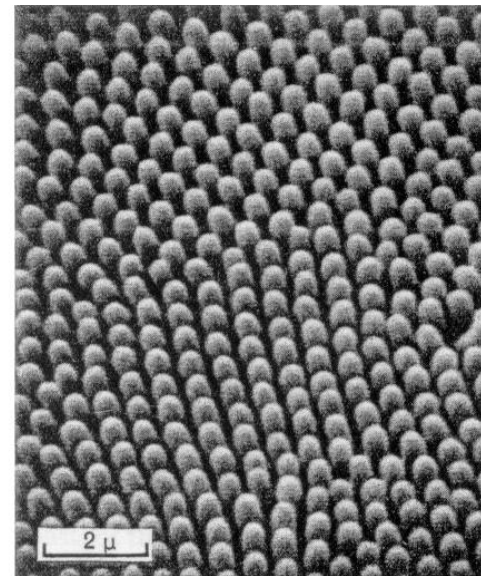
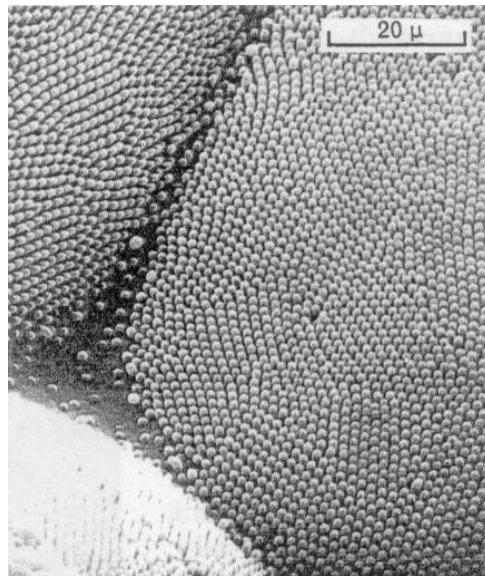


Micron-scale texturing

- micron –scale themes are based on the development of topographies that provide light with multiple opportunities to be absorbed
- reflectance can be as low as 1-2%
- easy to apply to C-Si (KOH etch)
- difficult to apply to other materials and thin materials (2-3 μm)

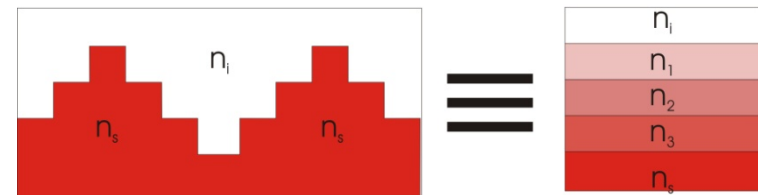


Biomimetic moth-eyes



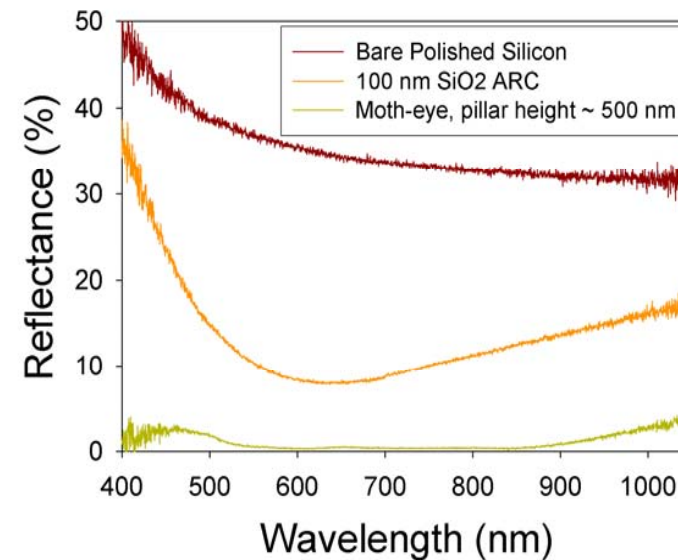
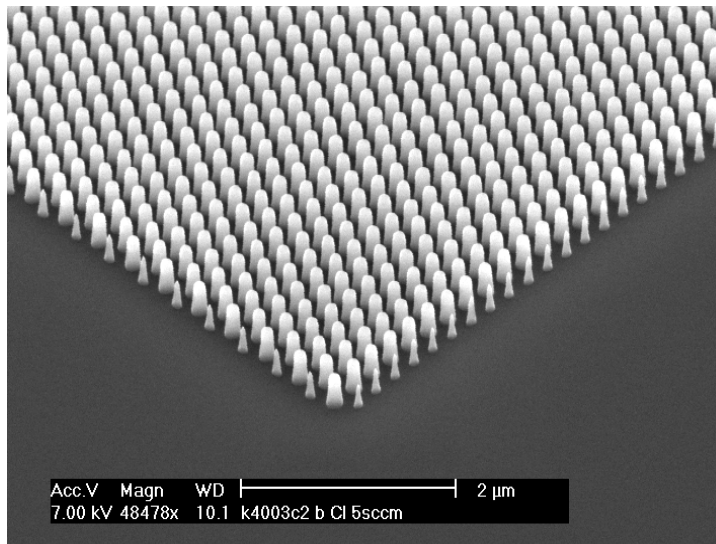
Bernhard, Endeavour vol 26, pp. 79-84, (1967)

- Arrays of subwavelength features
- Gradual change in refractive index from air into substrate



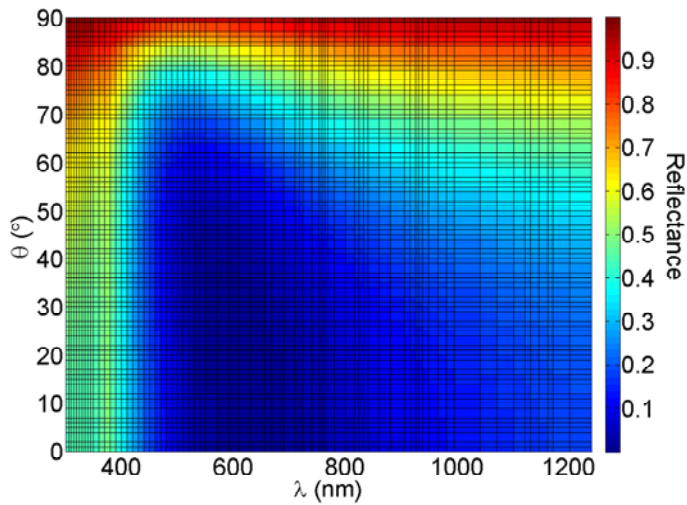
Biomimetic moth-eyes

- sub-wavelength patterning “creates a gradual change in refractive index and reduces reflection” – seen on moth-eyes
- our first structures were fabricated by e-beam and plasma etch

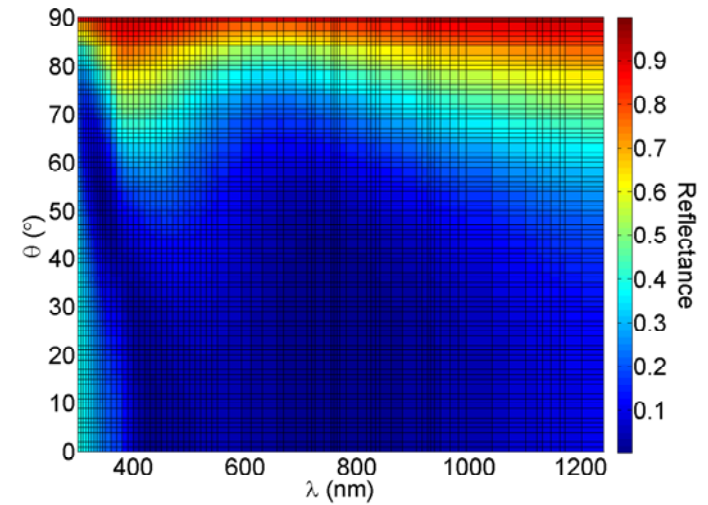


- first experimental results illustrates very low reflectance and evidence of structure that **can not be explained by effective medium theory**

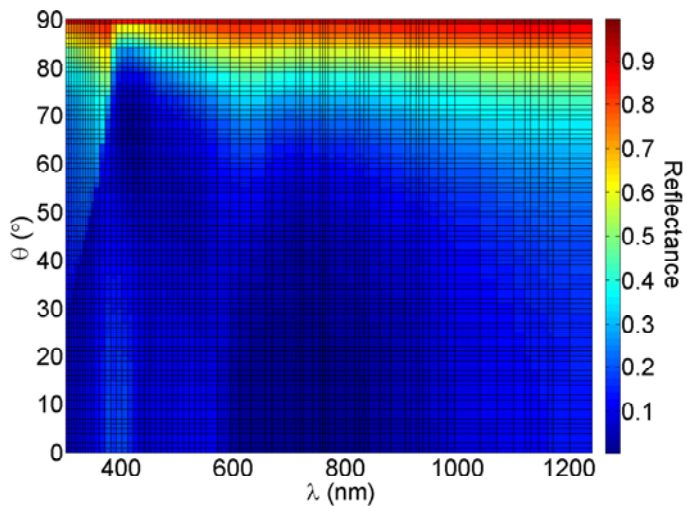
Biomimetic moth-eyes



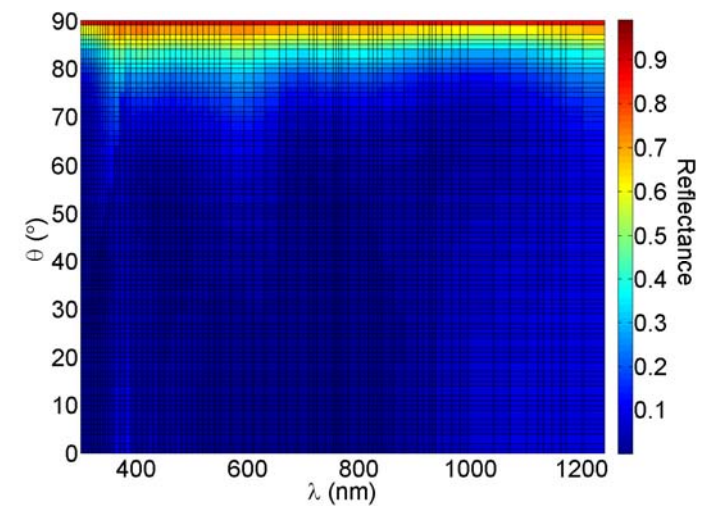
CeO SLAR



ZnS,MgF₂ DLAR



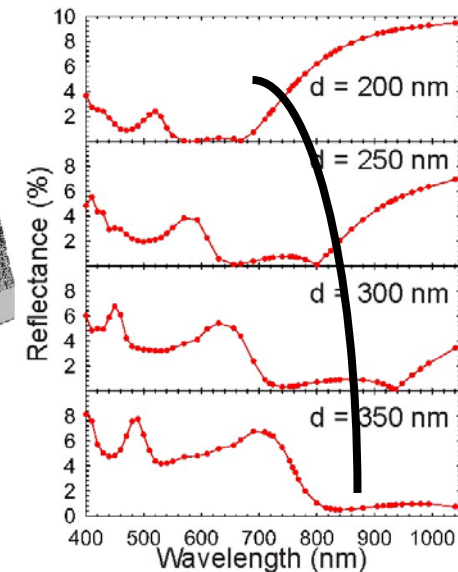
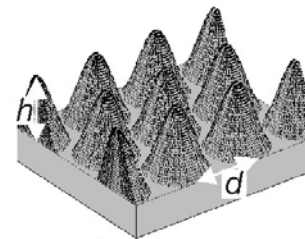
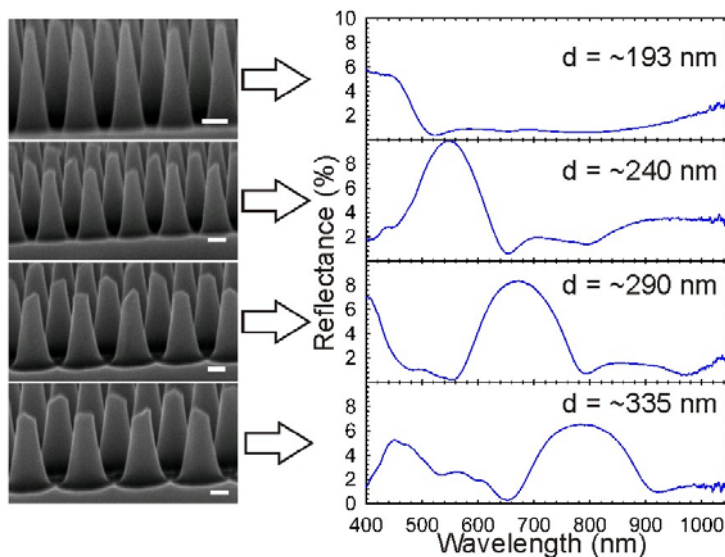
Moth-eye 250 nm



Moth-eye 500 nm

Tunable moth-eyes

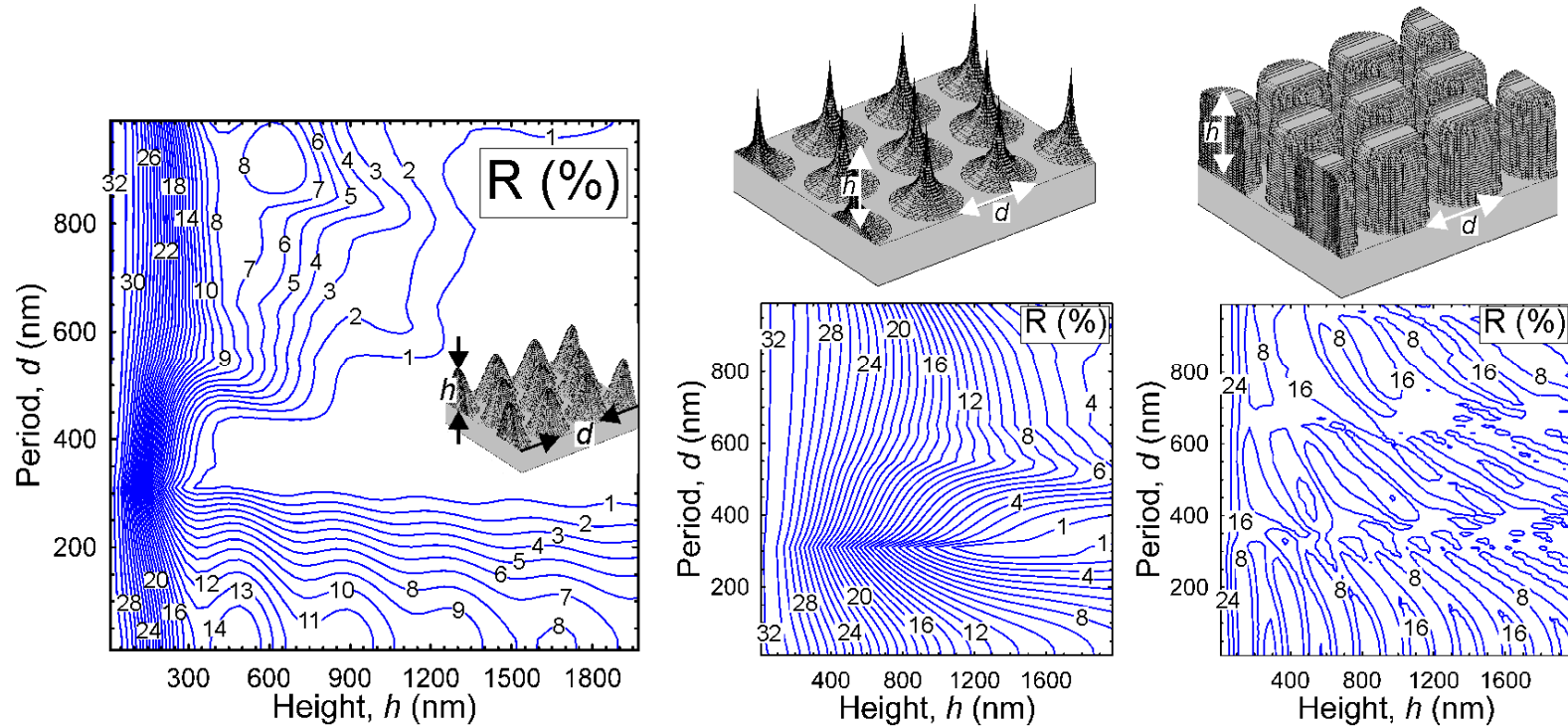
- changing height, shape and period of pillar profiles on the reflectance of silicon moth-eye arrays.
- Study reveals a low reflectance band which shifts with array period.



- samples by nano-imprint lithography

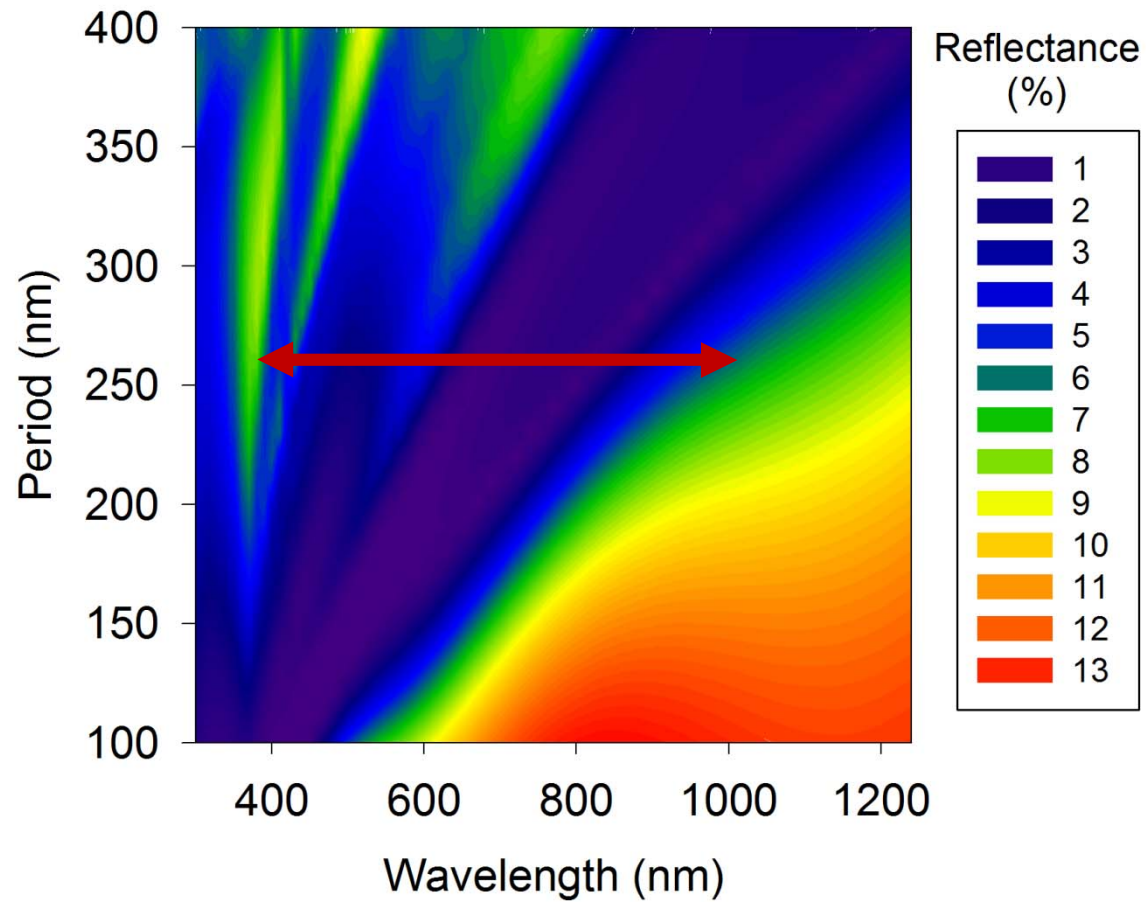
Biomimetic moth-eyes

- Pillar shape also has a dramatic effect on the reflectance properties.
- For highest performance pillar height, shape and array period should be optimized for the specific wavelength range of interest.



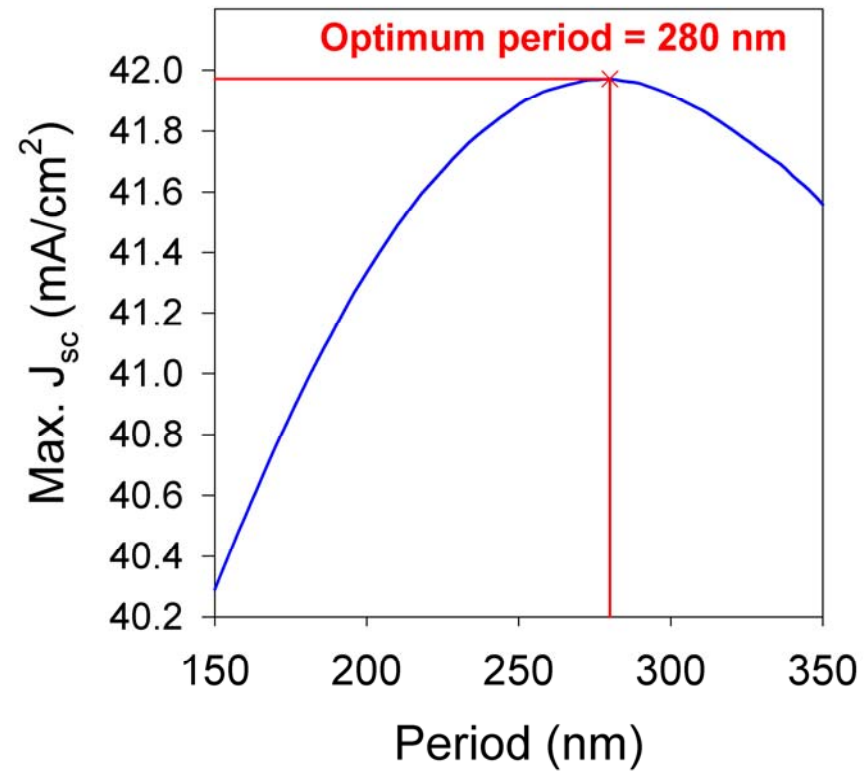
Design Detail...Period

Reflectance with period/wavelength (400nm height)



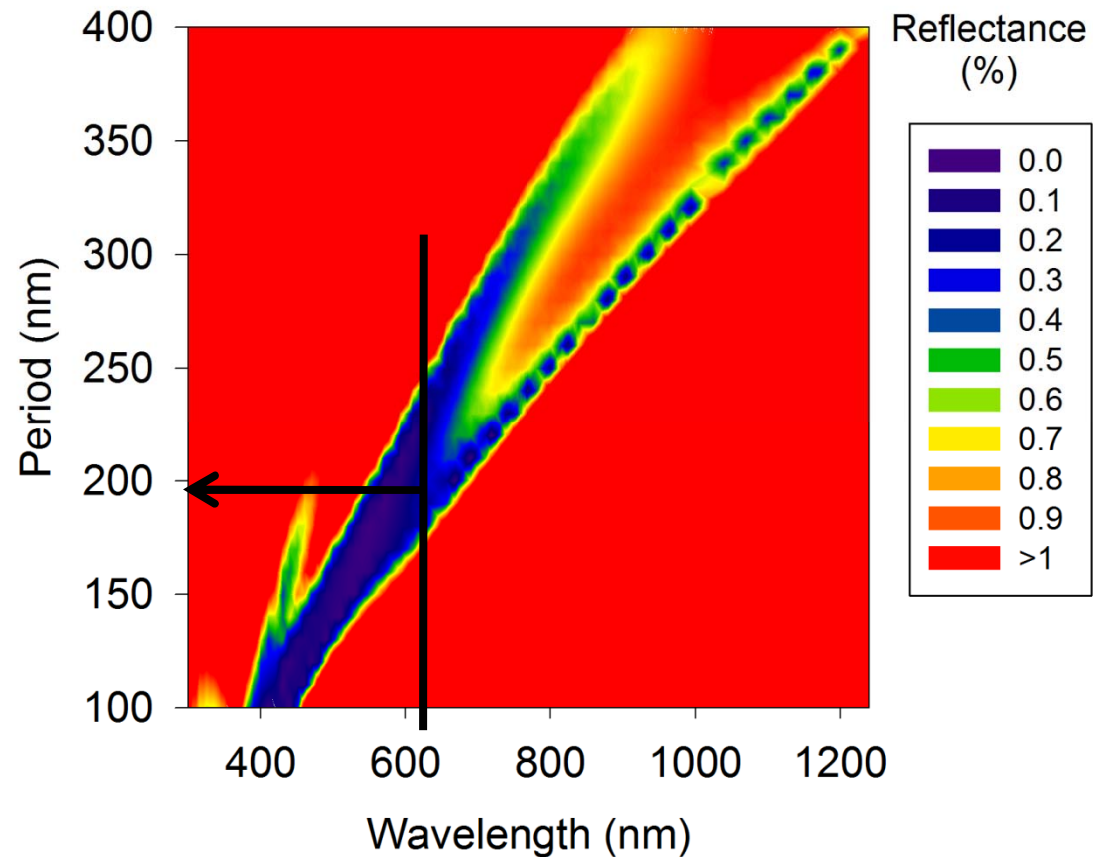
Biomimetic moth-eyes

Optimise periodicity by considering: $R(\lambda)$
 $QE(\lambda)$ and
 $AM1.5(\lambda)$



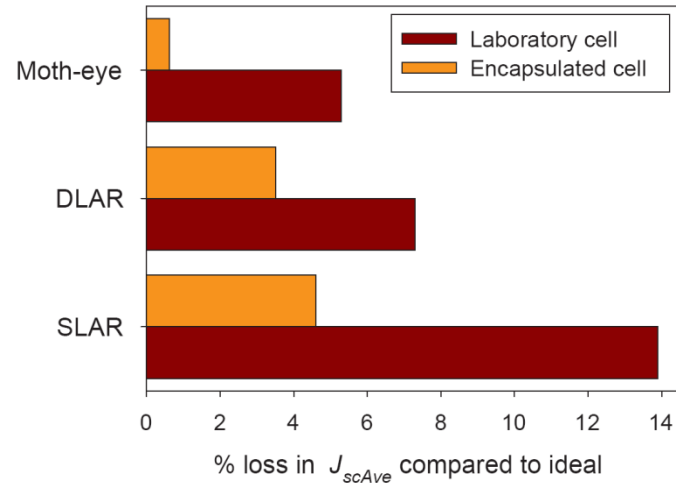
Design Detail...Period

Reflectance with period/wavelength (400nm height)



S. A. Boden and D. M. Bagnall, *Applied Physics Letters*, 93, 133108 (2008)

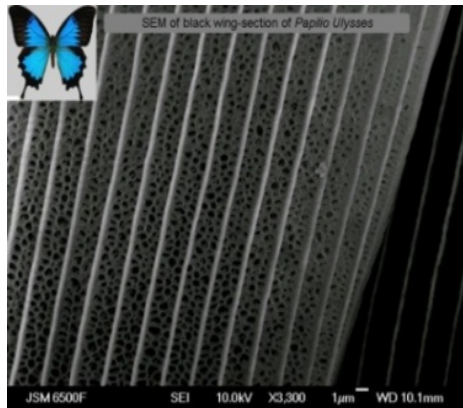
Sub-wavelength A/R



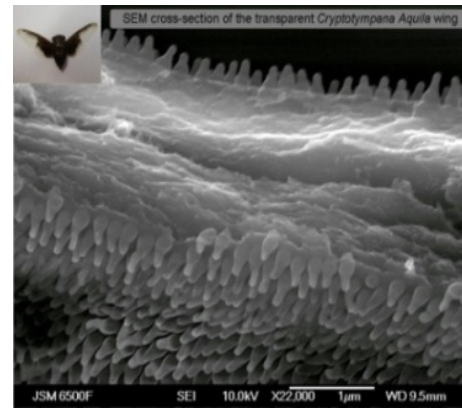
- moth-eye AR schemes are promising for thin film solar cells
- requires self-assembly/cheap fabrication
- nanoscale roughened surfaces might already be doing the job for some thin films

Other biomimetics

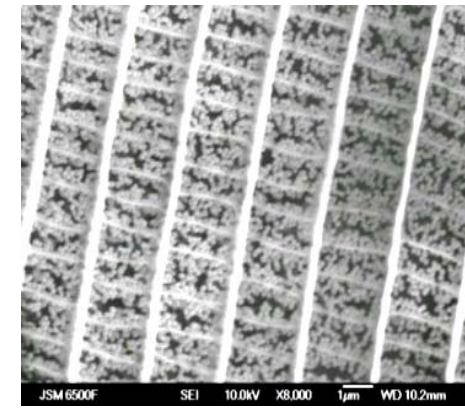
- Meanwhile, many other natural systems offer interesting prospects
- Each represents considerable challenge to fabricate or model



colour



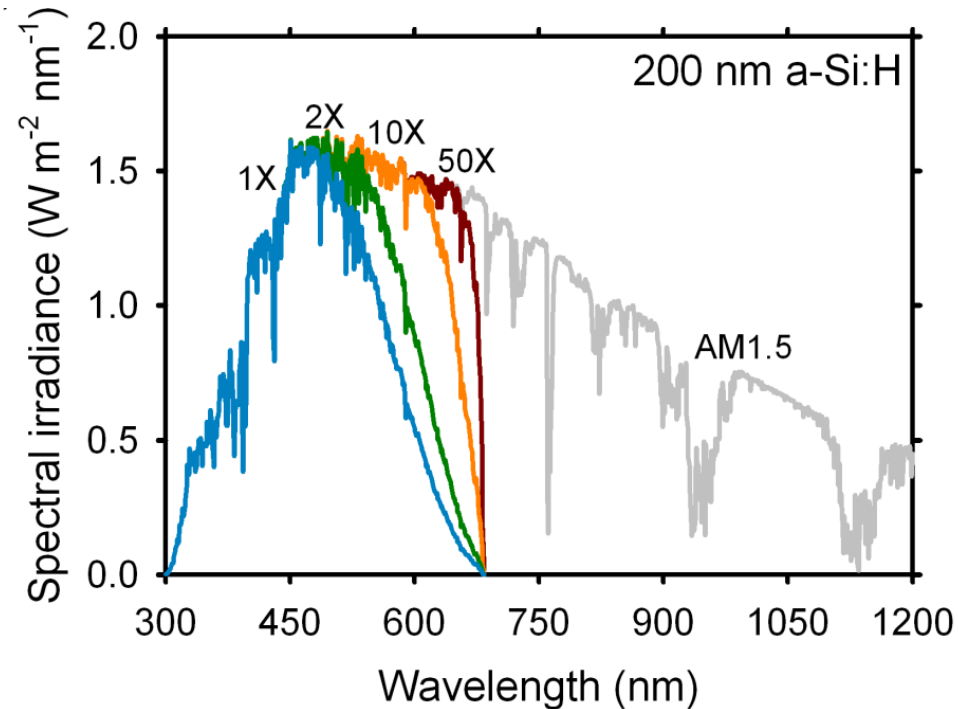
transparent



white

Light-trapping

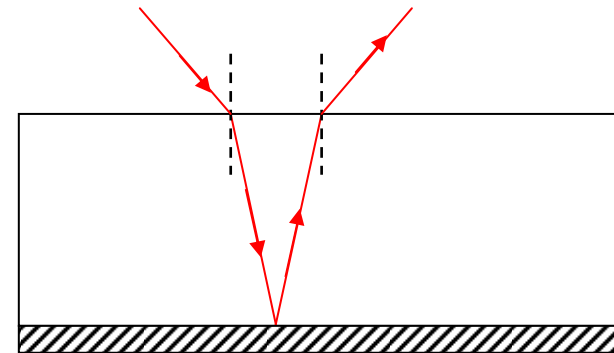
The case for light-trapping



- light-trapping can help all devices (enhance absorption or carrier collection, use less material)
- For a-Si, p-Si light-trapping is essential – but can it be improved?

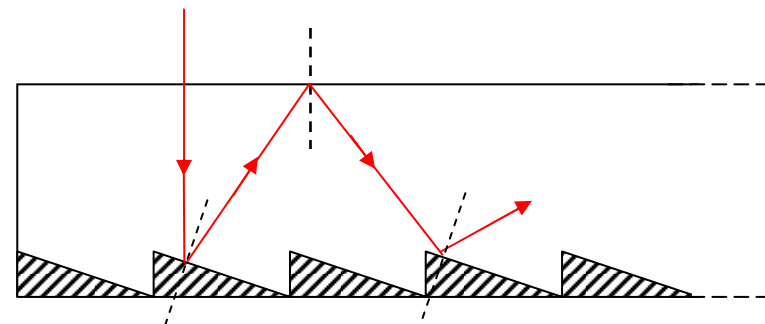
Classic solutions

- ensure reflection from the back surface of the solar cell (doubles the effective path – but in the highly symmetric scheme remaining light is decoupled at surface)

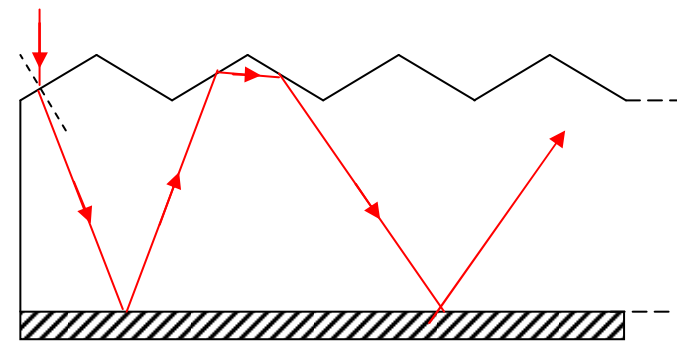


- asymmetric back-reflector ensures multiple reflections (but hard to manufacture)

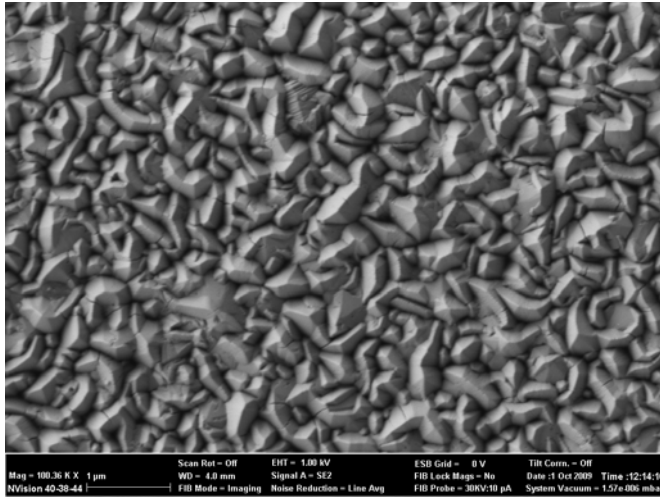
•R. H. Morf, in *Diffractive Optics for Industrial and Commercial Applications*, edited by Jari Turunen and Frank Wyrowski, Akademie Verlag GmbH, Berlin (1997) p361-389



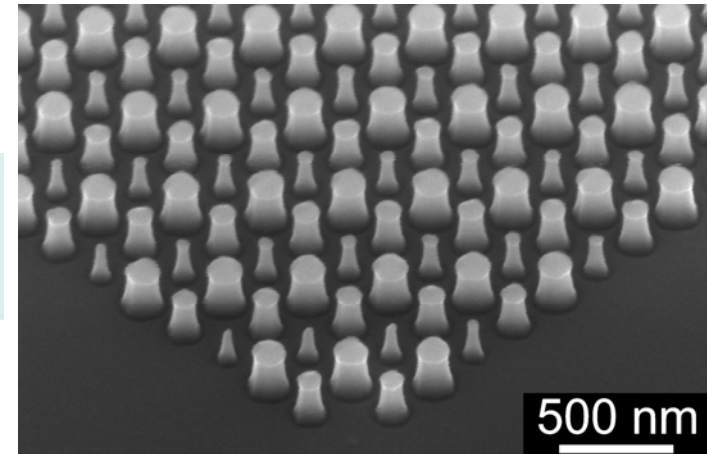
- diffuse scattering schemes can increase path-lengths by as much as 20x, but with some escape-cone losses



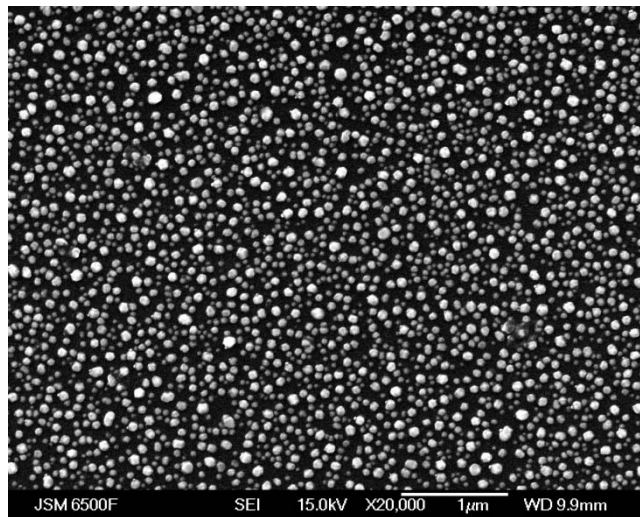
Light-trapping mechanisms



Texturing
(Lambertian scattering)

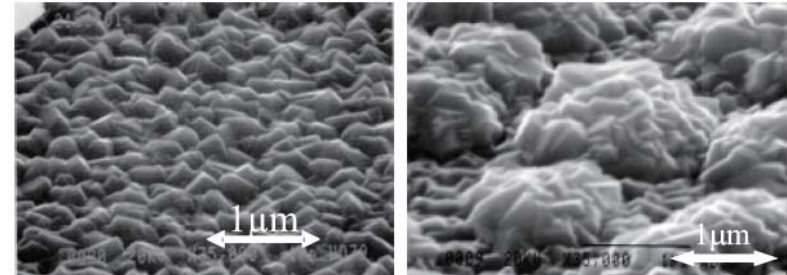
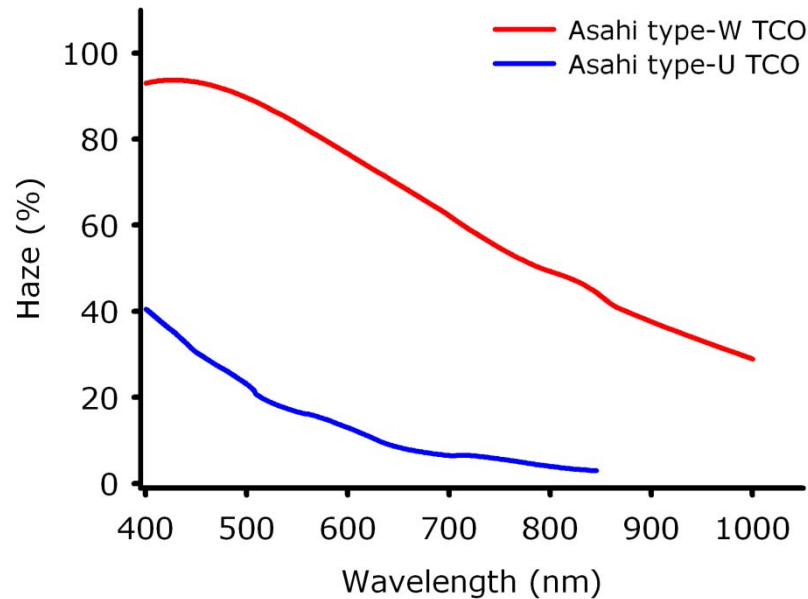


Periodic structures
(diffraction, photonics)



Plasmonic
(preferential scattering)

Textured Surface



Asahi type-U TCO

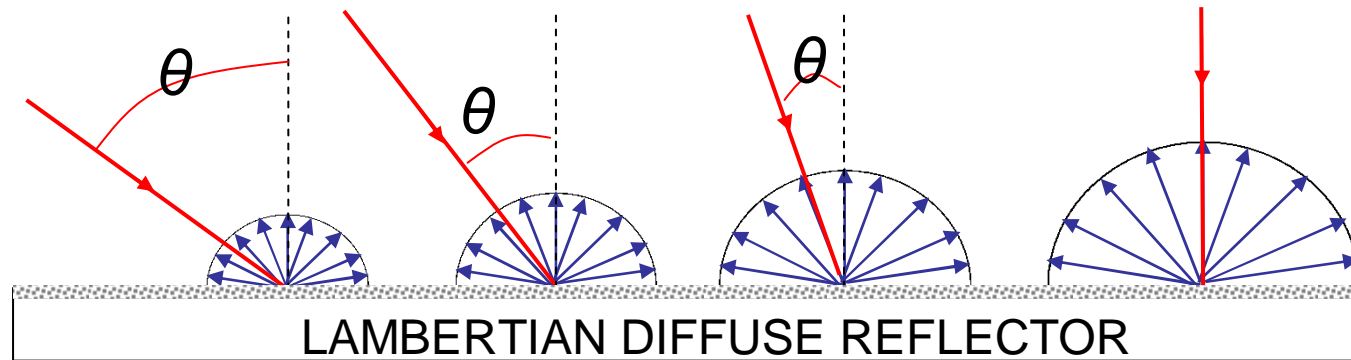
Asahi type-W TCO

[N.Taneda, T. Oyama and K. Sato,
Proceedings of International PVSEC-17, 2007]

- Textured TCO on glass can be readily provided by appropriate growth or etching regime
- Asahi “U” type is commercial product for a-Si devices
- Required to provide optimum scattering 500-700nm wavelengths
- Classically measured by “haze” value

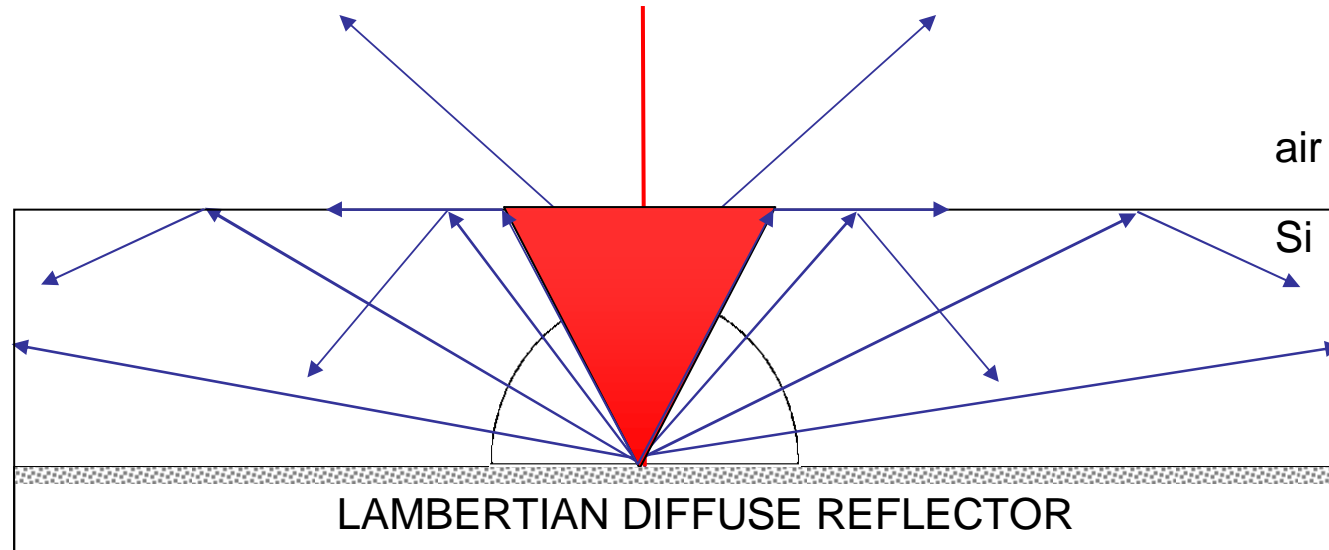
Lambertian Scattering

$$I_{diffuse} = k_d I_{light} \cos \theta$$



- Incoming light is scattered equally in all directions
- Viewed brightness is independent of viewing direction
- Brightness does depend on direction of illumination

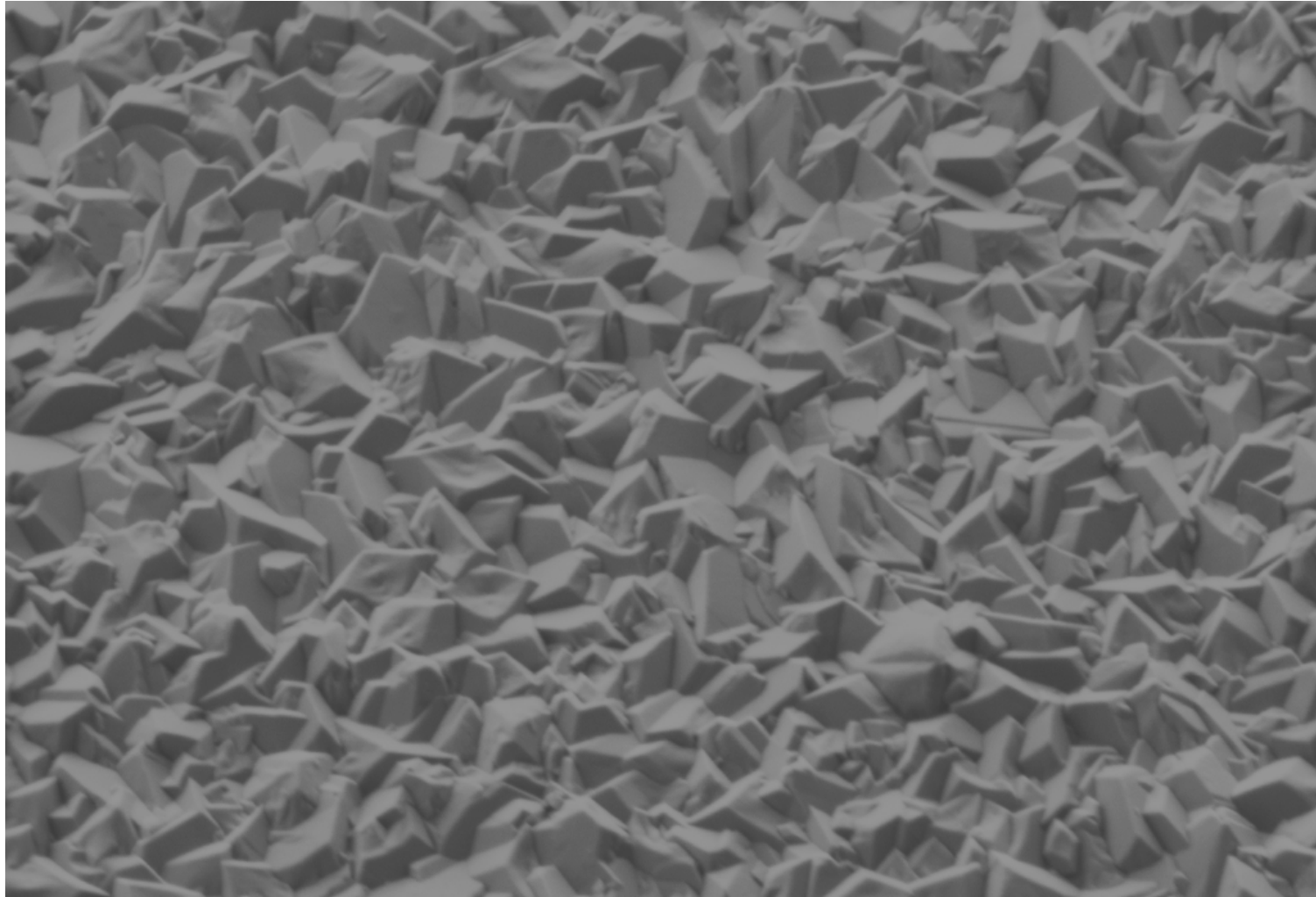
Light-trapping



- Fraction of light reflected by total internal reflection = $1 - \frac{1}{n^2}$
- For Si, $n=3.4$. Therefore, **91%** of light is reflected back into the cell each time it reaches the top surface
- “**escape cone**” losses account for **9%**
- Overall, the path length can be increased by about a **factor of 50**

Textured TCOs

Asahi "U" type



Mag = 149.27 K X 200 nm
NVision 40-38-44

Stage at T = 30.0 °
WD = 3.4 mm
FIB Mode = Imaging

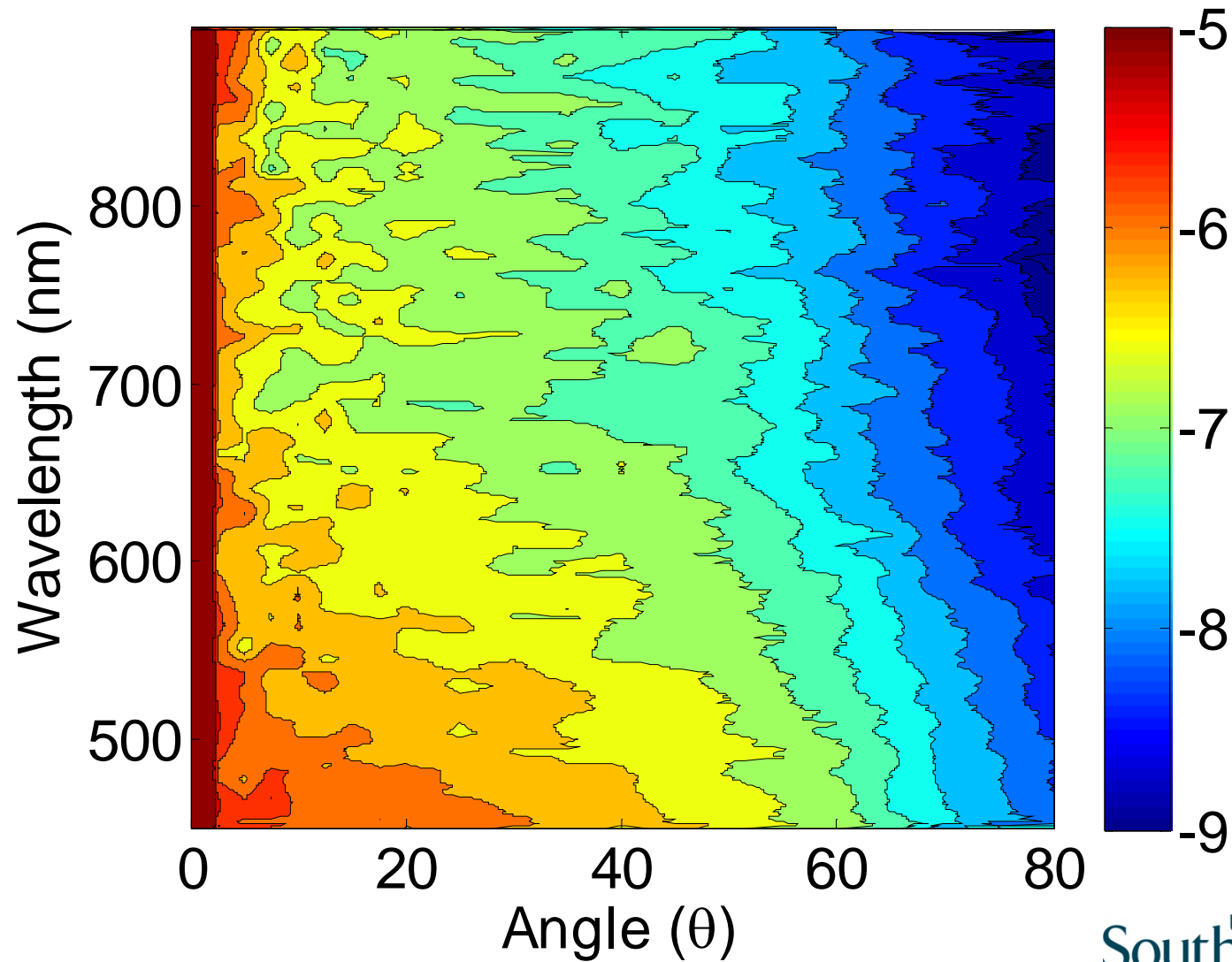
EHT = 1.00 kV
Signal A = SE2
Noise Reduction = Line Avg

ESB Grid = 0 V
FIB Lock Mags = No
FIB Probe = 30KV:80 pA

Tilt Corr. = Off Tilt Angle = 54.0
Date :16 Nov 2009 Time :12:38:57
System Vacuum = 1.18e-006 mbar

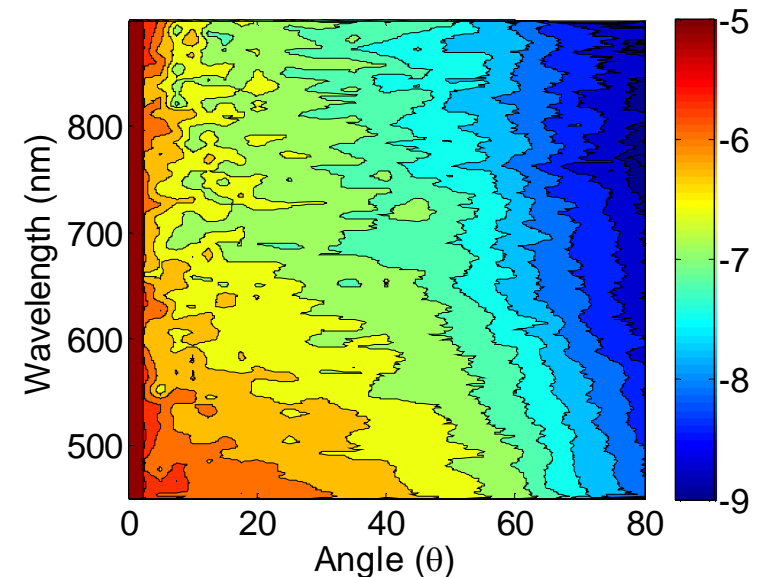
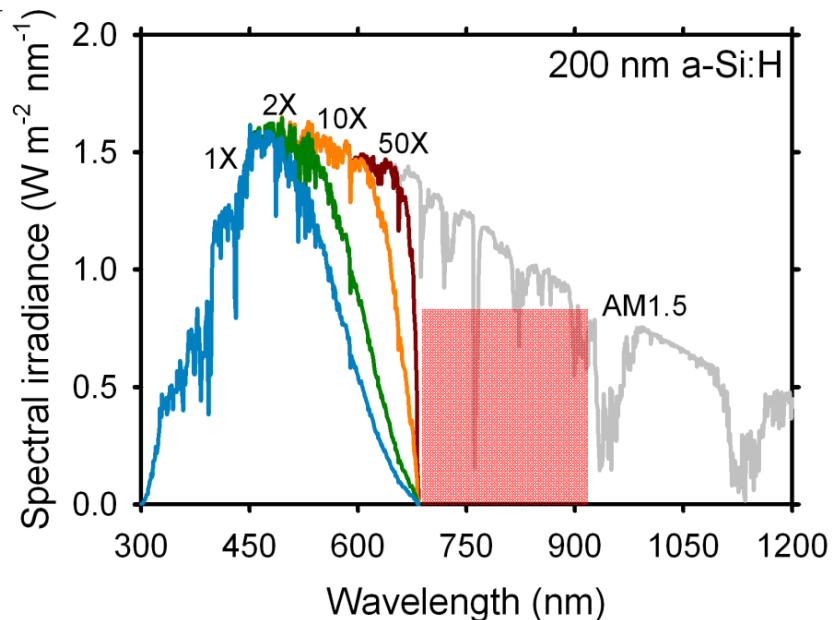
White-light angular scattering

Asahi "U" type

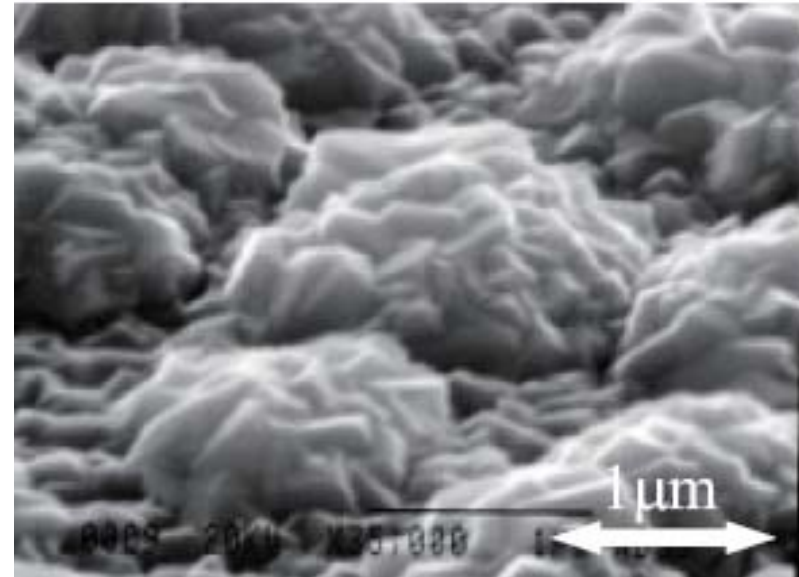
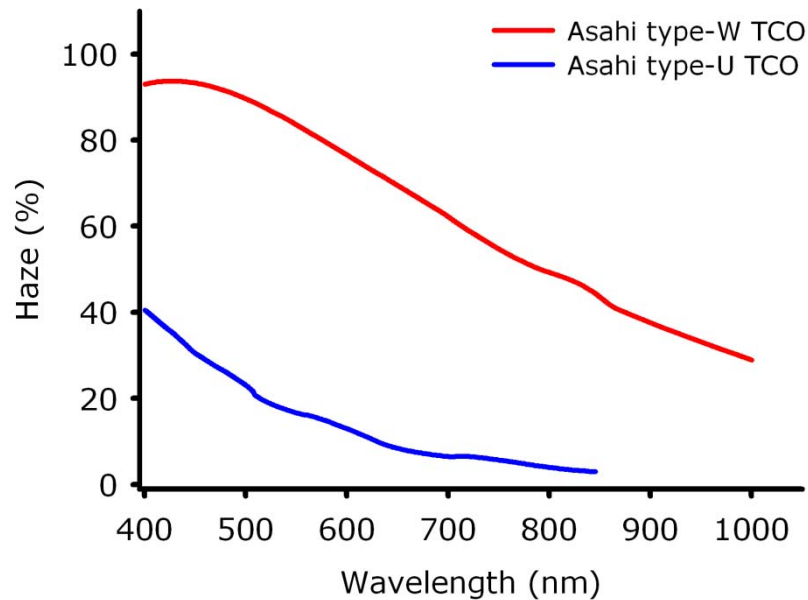


Feature size dependence

- The main problem with texturing is that long-wavelength scattering requires large feature size
- Large features sizes are difficult to grow on
- Commercial designs represent a compromise between optical performance and device performance
- Asahi “U-Type” is used for a-Si
- Rougher surfaces are required for “**micromorph**” devices



Light-trapping for longer wavelengths



Asahi type-W TCO

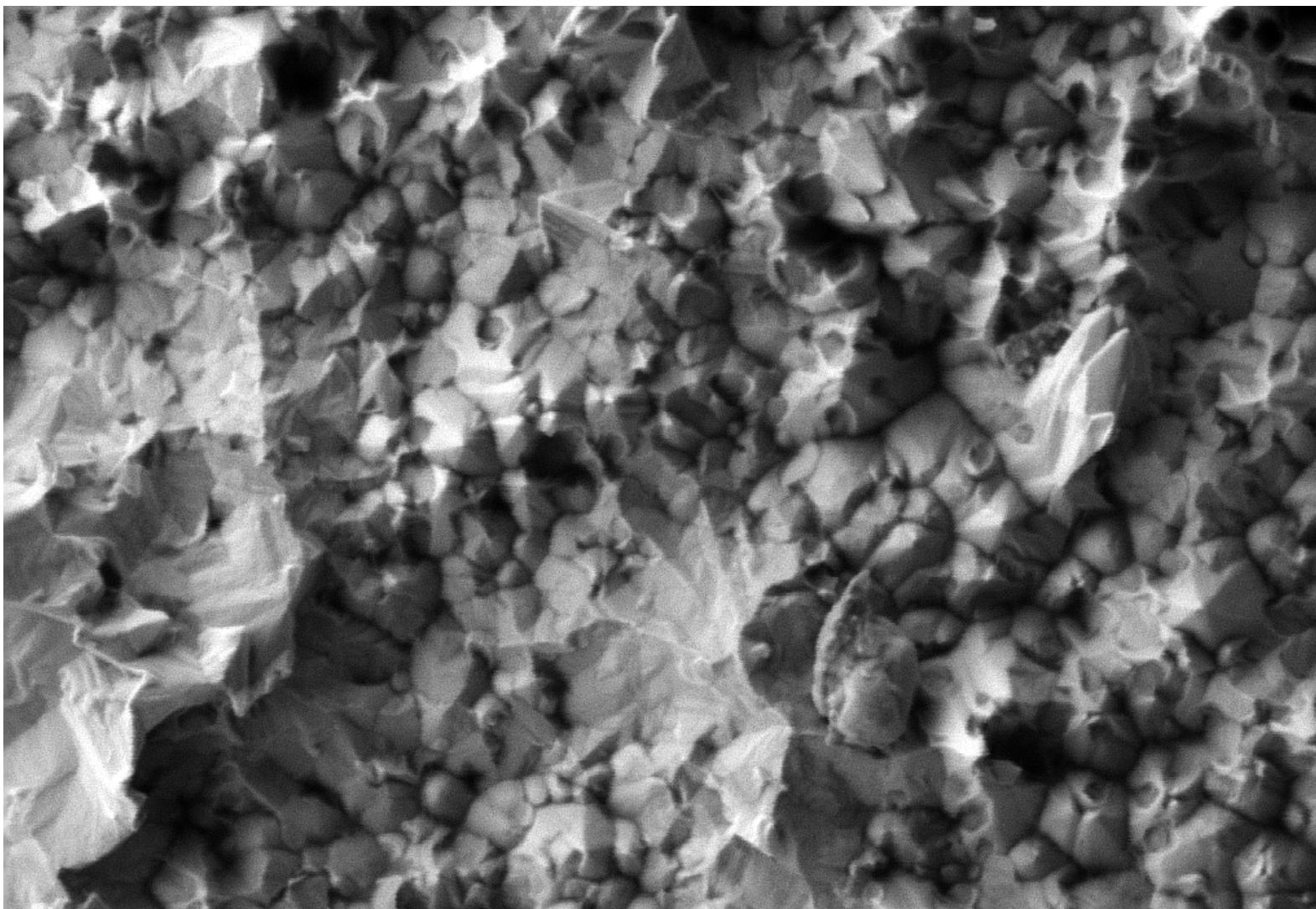
[N.Taneda, T. Oyama and K. Sato, Proceedings of International PVSEC-17, 2007]

- Can metal nanoparticles offer an alternative scattering mechanism?

White-light angular scattering

EPVSOLAR

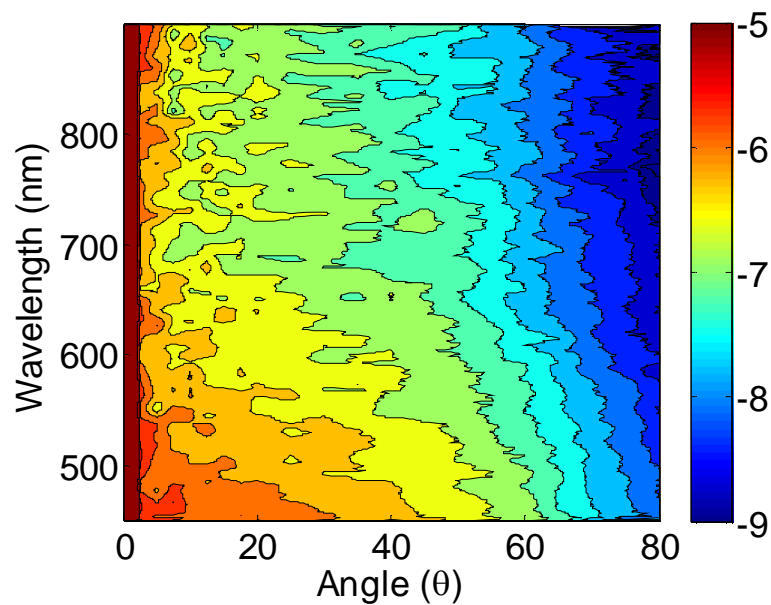
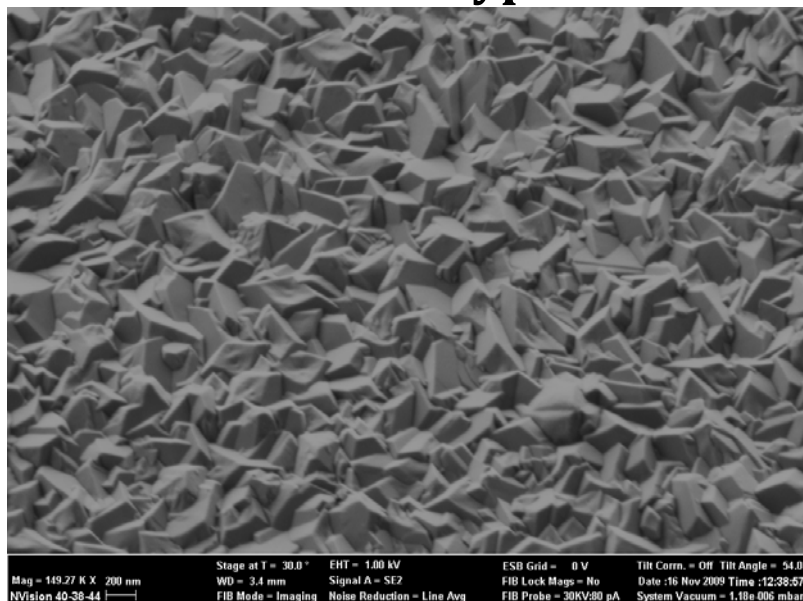
EPV 386



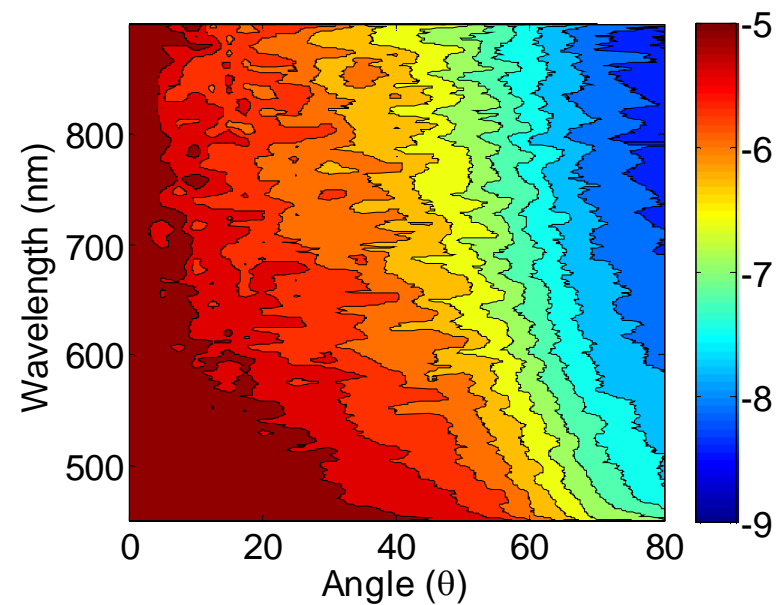
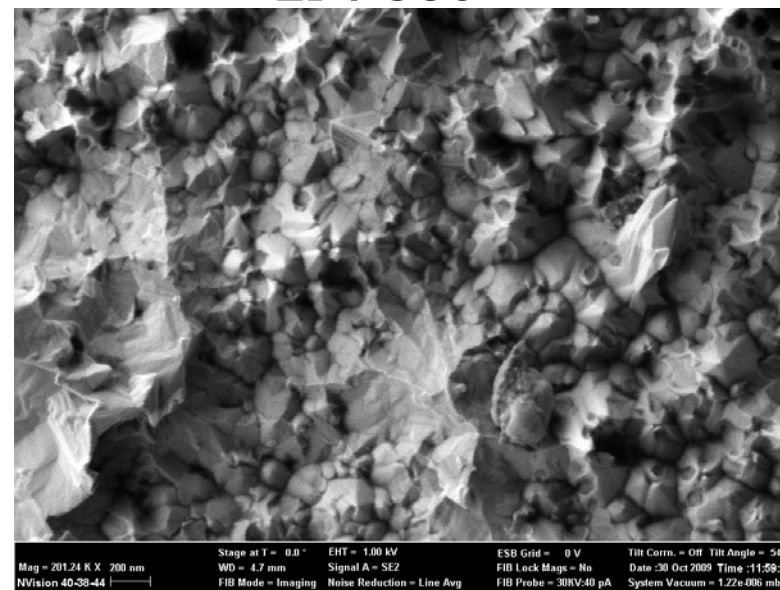
Mag = 201.24 K X 200 nm	Stage at T = 0.0 °	EHT = 1.00 kV	ESB Grid = 0 V	Tilt Corr. = Off Tilt Angle = 54.0
NVision 40-38-44	WD = 4.7 mm	Signal A = SE2	FIB Lock Mags = No	Date :30 Oct 2009 Time :11:59:28
	FIB Mode = Imaging	Noise Reduction = Line Avg	FIB Probe = 30KV:40 pA	System Vacuum = 1.22e-006 mbar

White-light angular scattering

Asahi "U" type



EPV 386

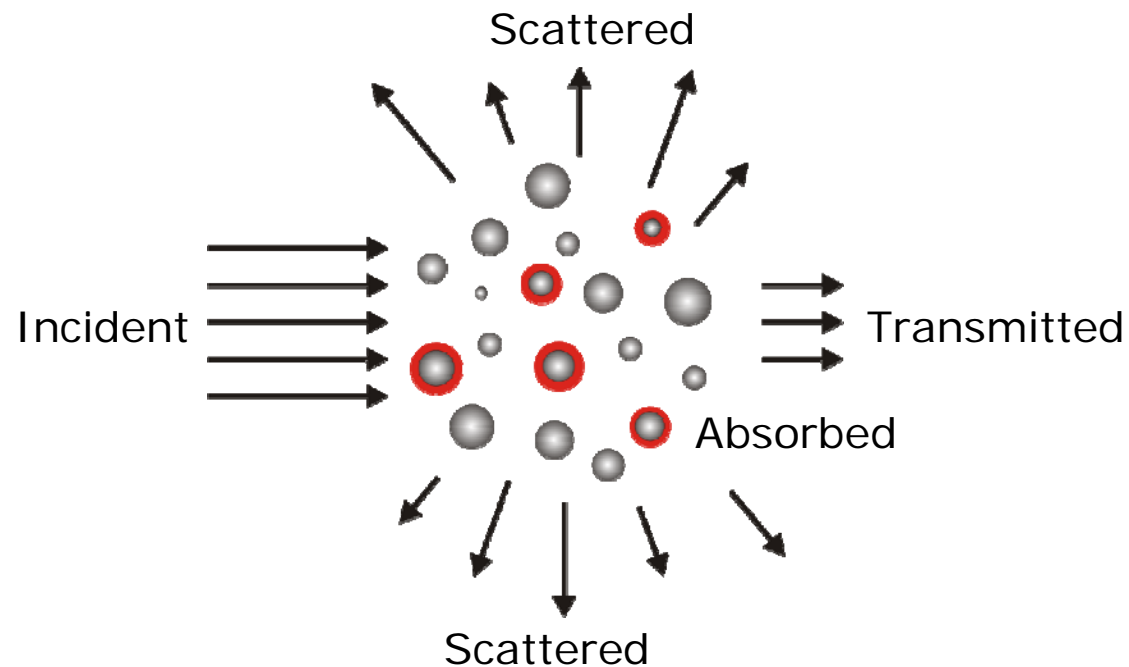


Plasmonic Light-trapping

Can metal nanoparticles offer an alternative scattering mechanism?

Plasmonic light-trapping

- The interaction of light with metal nanoparticles can lead to the generation of localised surface plasmons (LSP).



Extinction = Scattering + Absorption

Simulations

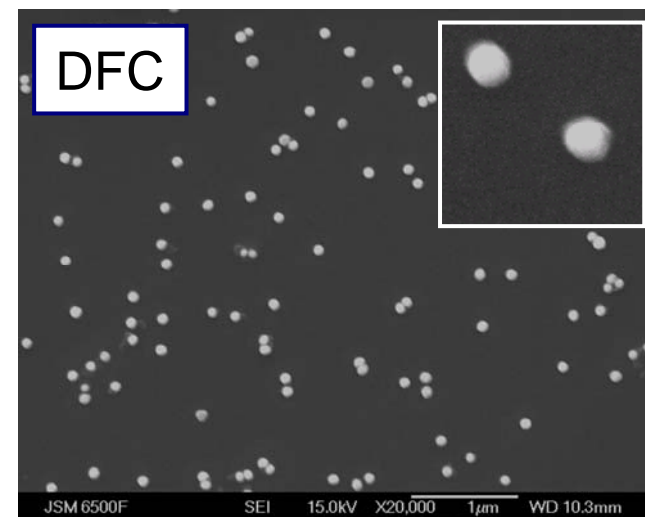
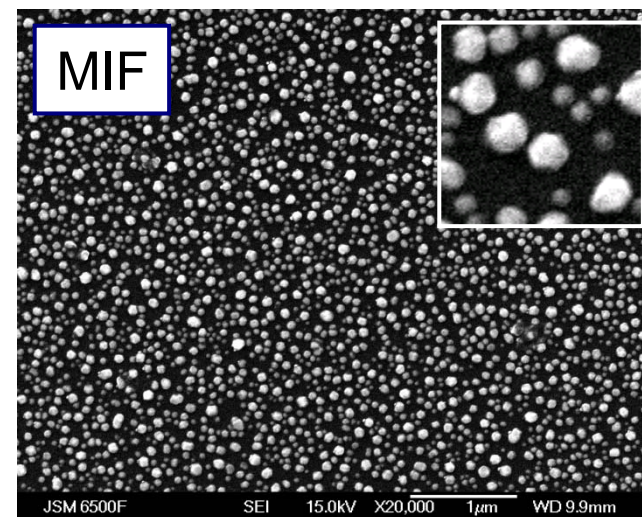
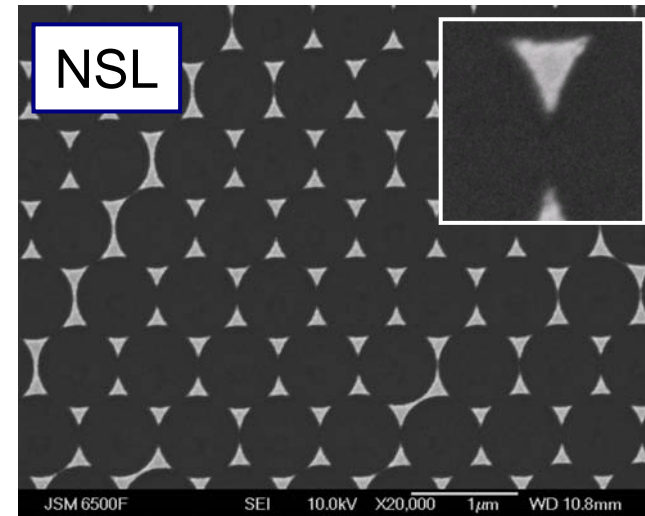
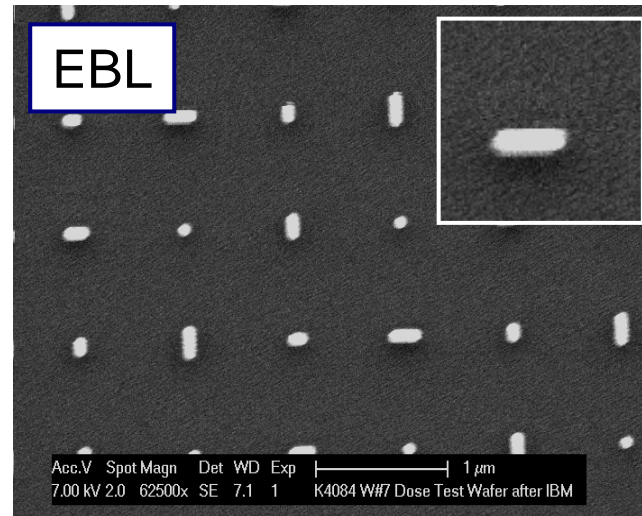
Spheres : Mie theory codes (BHMIE and BHCOAT)
(Bohren and Huffman)

Spheroids : Separation of variables (SVM)
(Voshchinnikov and Farafonov)

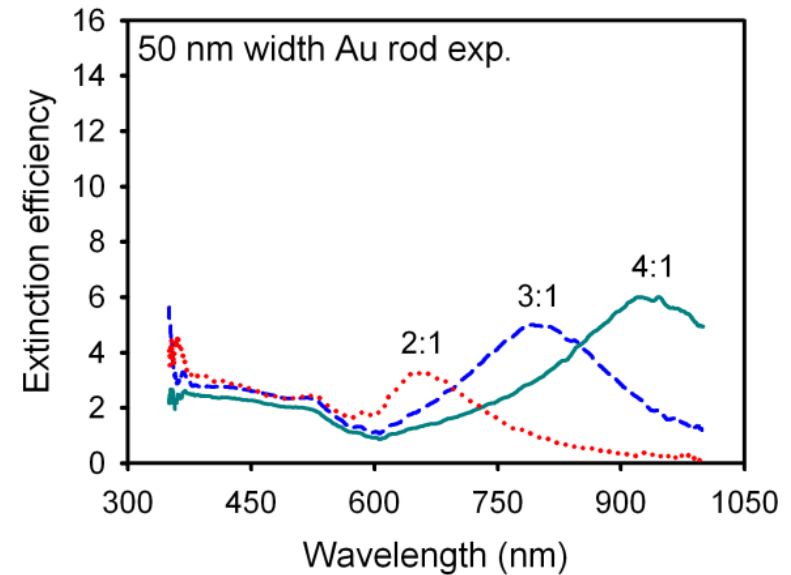
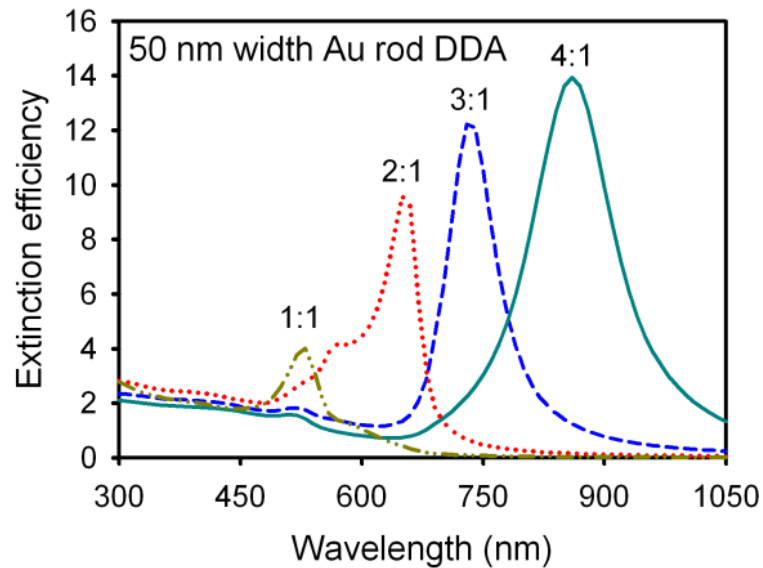
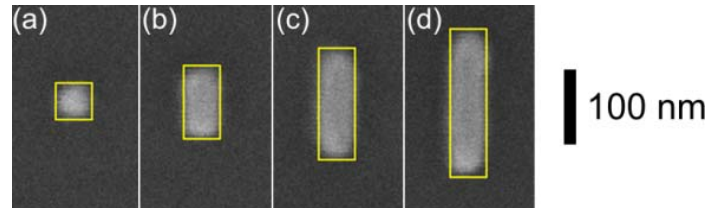
Prisms etc : Discrete Dipole Analysis (DDA) (DDSCAT)
(Draine and Flatau)

(refractive index data taken from Palik)

Fabrication of metal nanoparticles



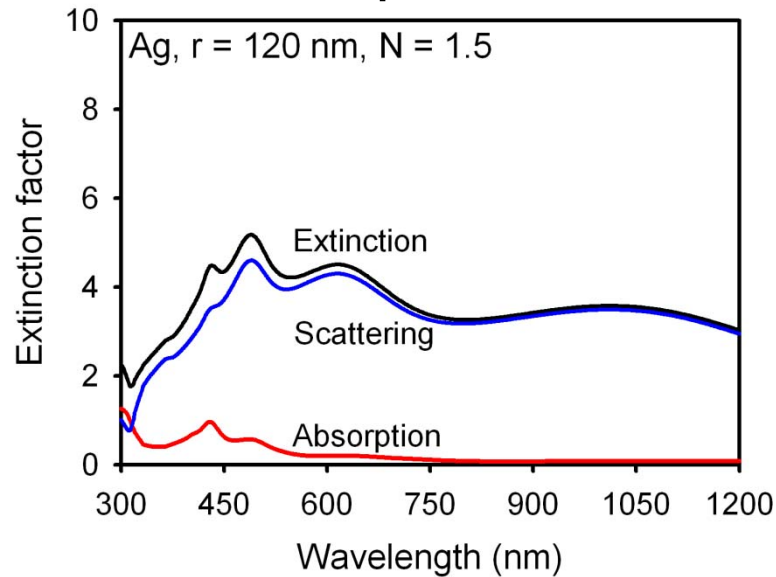
Electron-beam lithography: aspect ratio



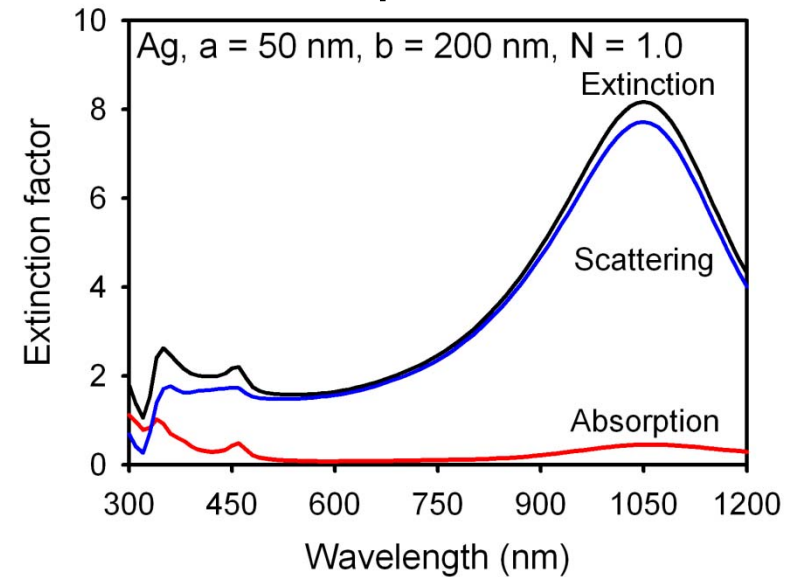
- rectangles can be produced (chemically) and offer excellent extinction at near bandedge

Optimized scattering

Spheres



Spheroids



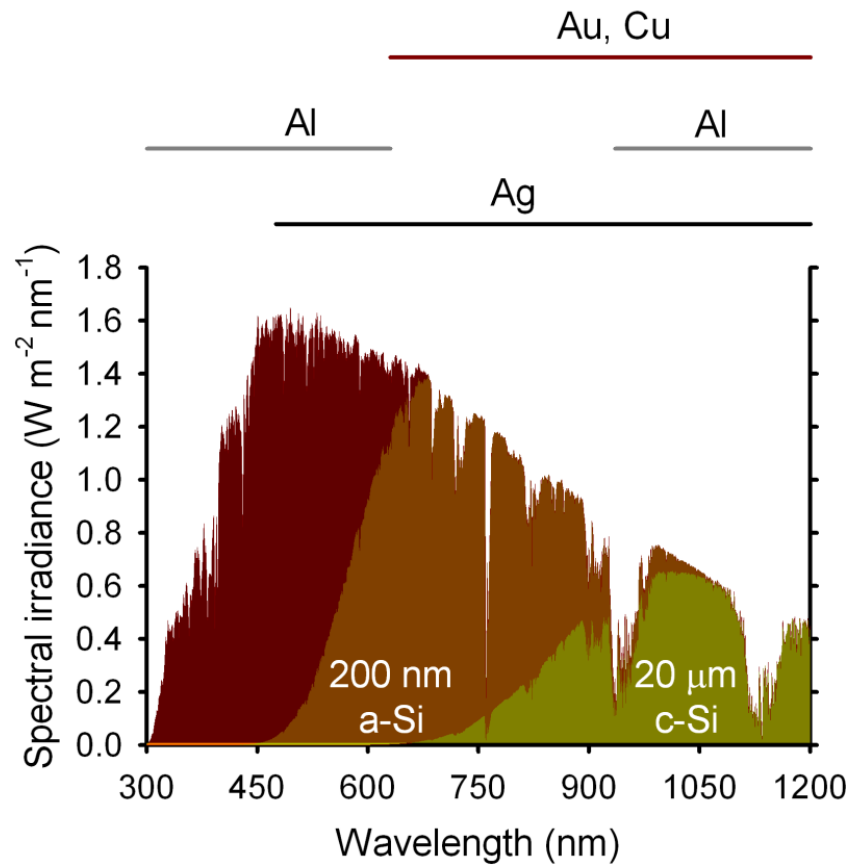
Small particles are highly absorbing, large particles highly scattering

Absorption : good for organic, bad for inorganic

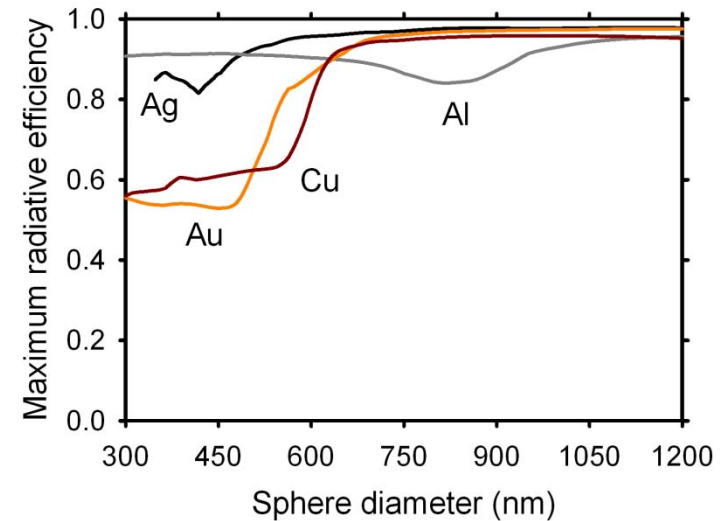
Scattering : good for all pv (part of light-trapping scheme)

Choice of metal

$Q_{rad} > 0.9$

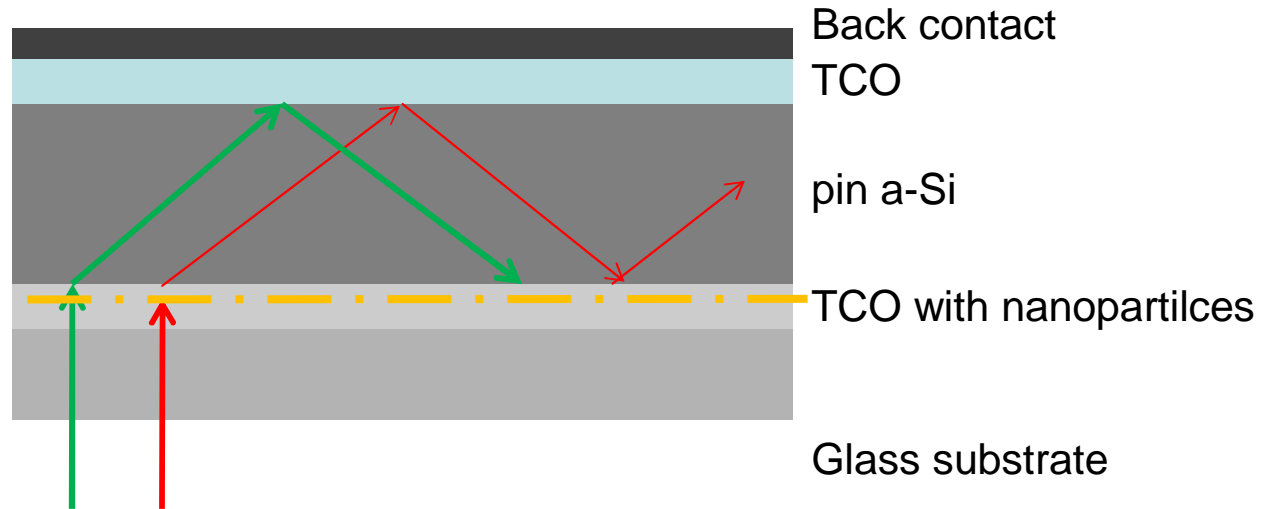


Spectrum present at rear
of two devices

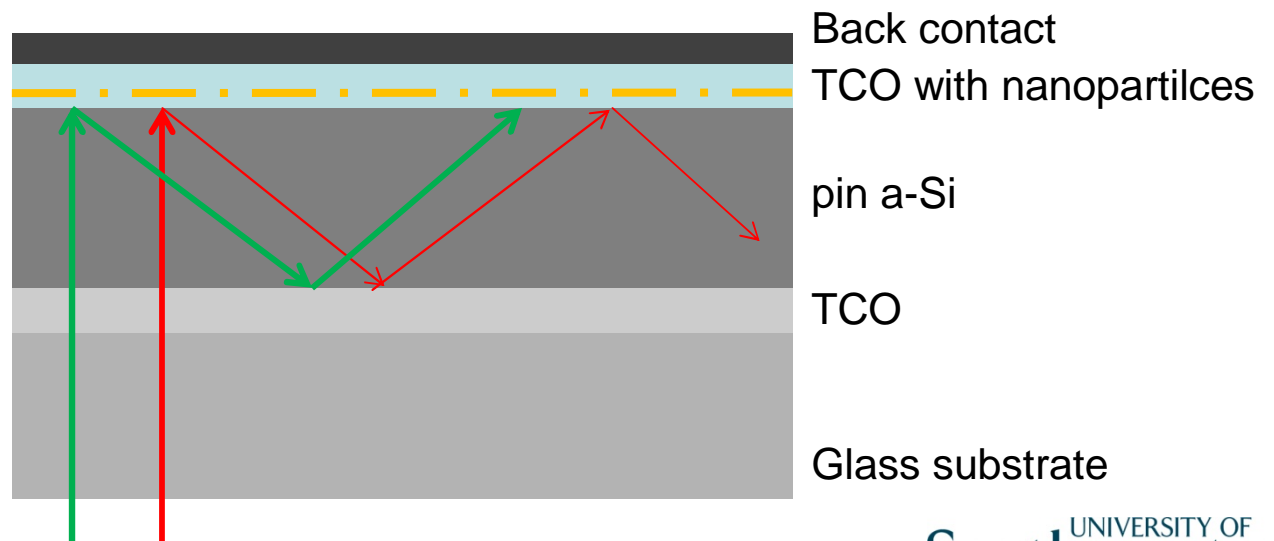


“Plasmonic” a-Si:H solar cells

Front



Back



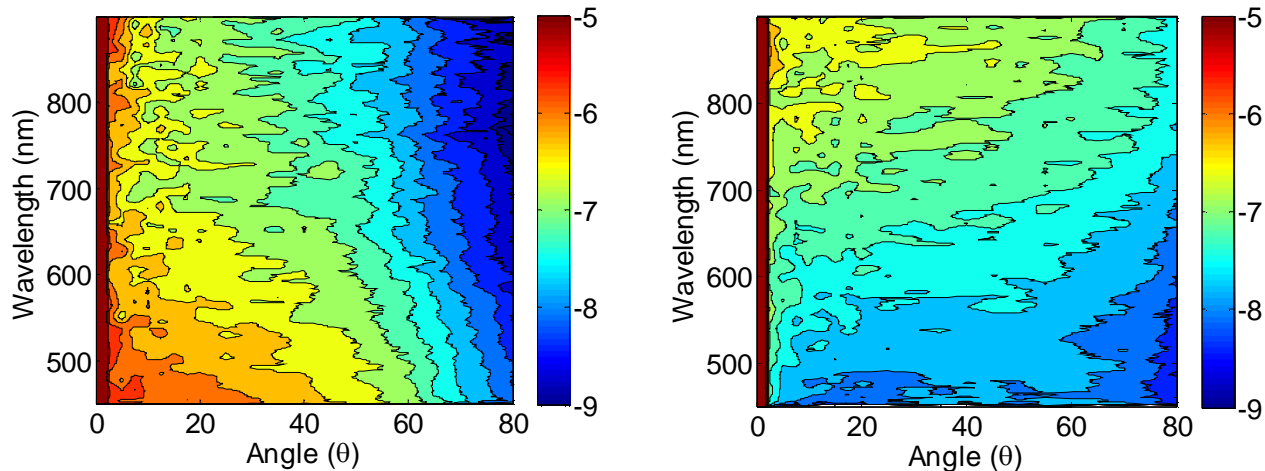
Design Rules

You should make sure you :

- chose a particle size and shape that **maximises scattering** in the region of low absorption (i.e. the band edge)
- **minimise absorption** in the metal across entire spectral range (assuming multiple scattering events small absorption will be multiplied 10 fold)
- **select the metal carefully**
- insert the **plasmonic layer at the back of the device** (short wavelength absorption is unavoidable, avoids surface reflection)
- use **large asymmetric particles** as this produces high scattering efficiency at long wavelengths
- **spread the particles about** (coupling leads to loss)
- **randomly distribute particles** (avoid diffraction) or else take diffraction into account.
- **randomly orientate particles** (polarization) or else have vertical & horizontal features
- understand that your metal nanoparticles change the optical properties of the TCO they sit in (consider reflection and coupling to back contact and antireflection)

Conclusions

- Plasmonic enhancement of an inorganic thin film solar cell has yet to be demonstrated
- First thin film “plasmonic devices” will exploit scattering in conjunction with texturing

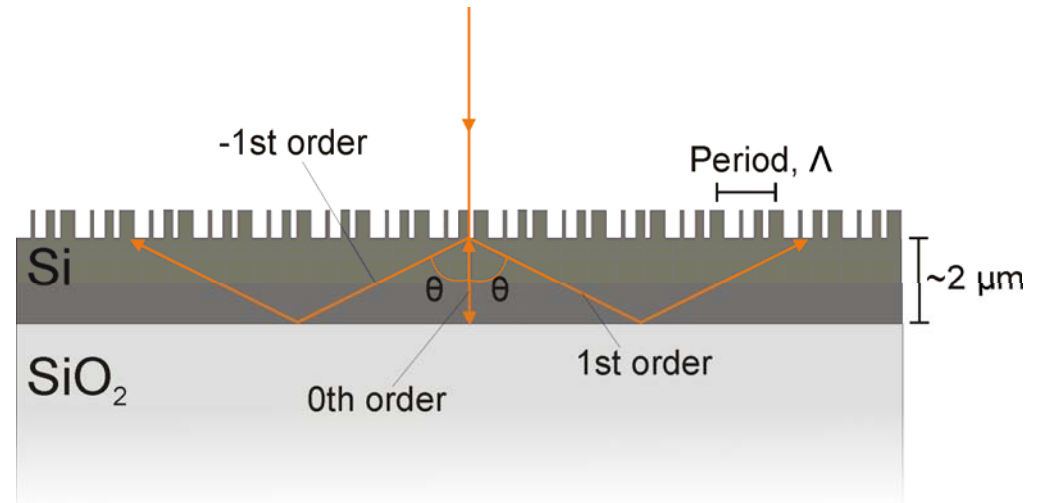
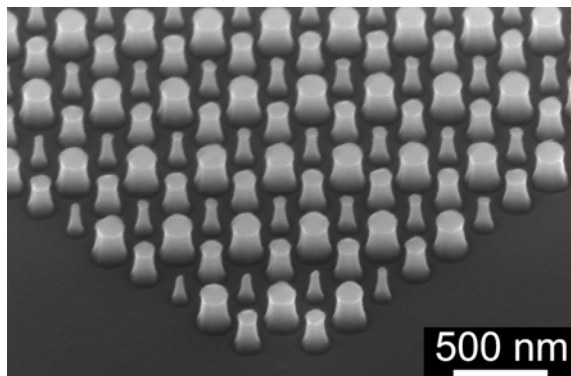


- Enhanced absorption may feature in organic systems (will be harder to use for inorganic)
- Second generation of inorganic plasmonic devices might utilise preferential scattering and diffraction to allow ultra-thin devices

Photonic Light-trapping

“Photonic” light-trapping

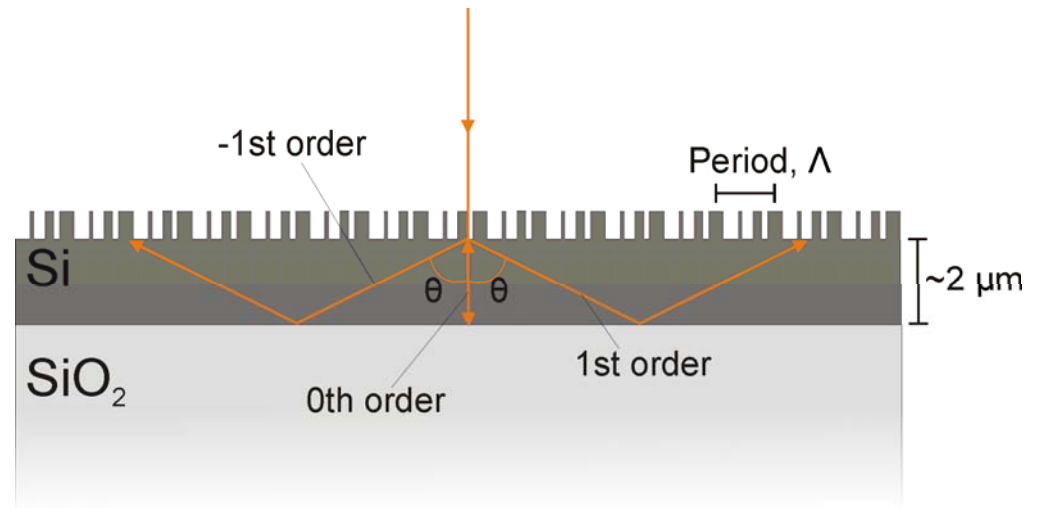
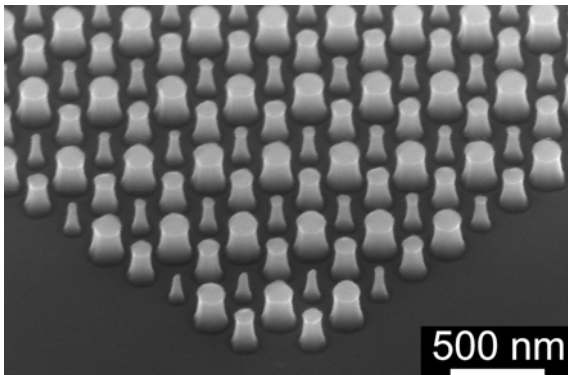
- We’ve looked at random scattering and plasmonic scattering
- The third light-trapping technique could be diffraction
- Techniques commonly used in photonics for coupling in waveguides



- We have found that blazed diffraction gratings can be effective (90%) for 200nm spectral range
- rather expensive to produce for little benefit

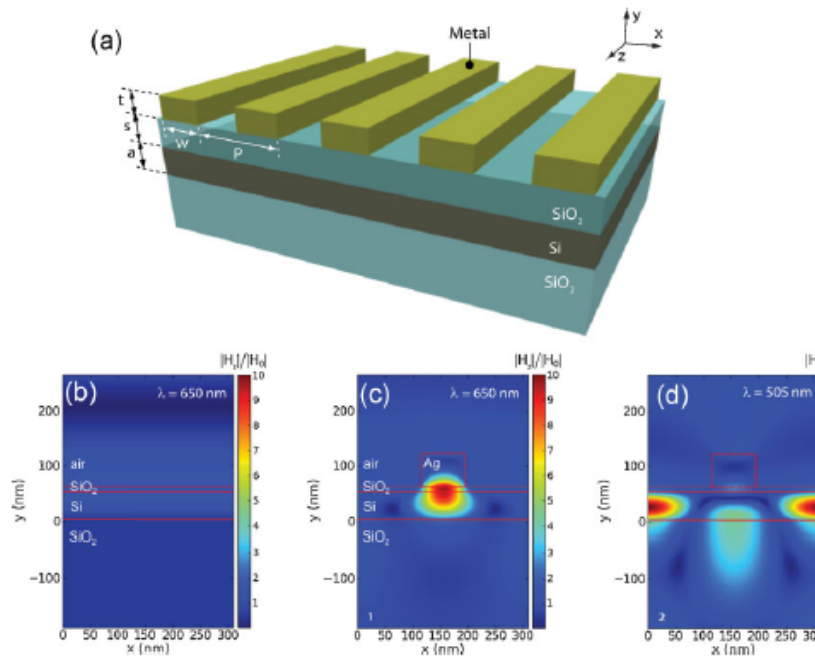
“Photonic” light-trapping

- We’ve looked at random scattering and plasmonic scattering
- The third light-trapping technique could be diffraction

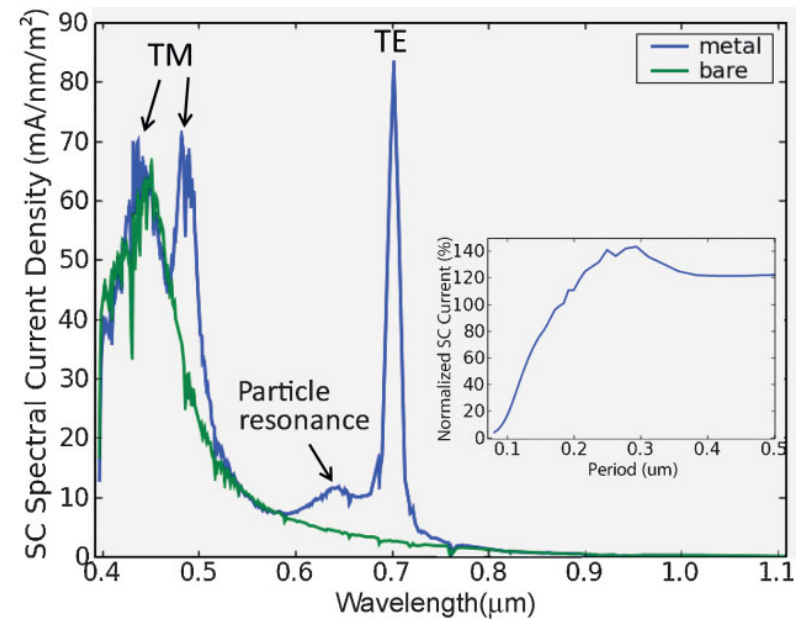


Plasmonic + Photonic Light-trapping

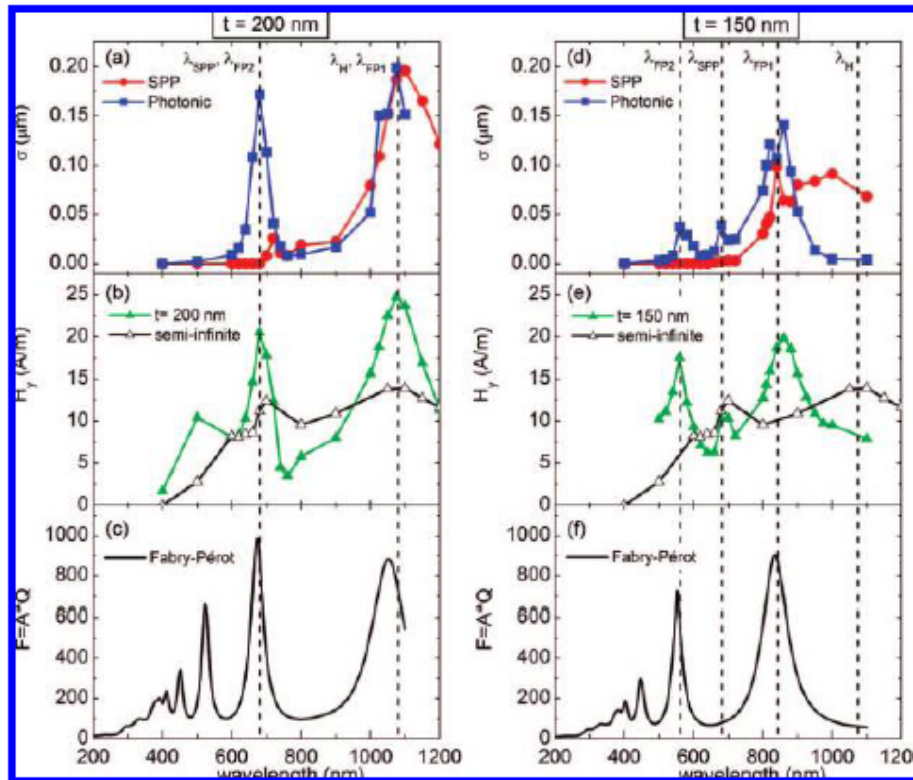
Gratings



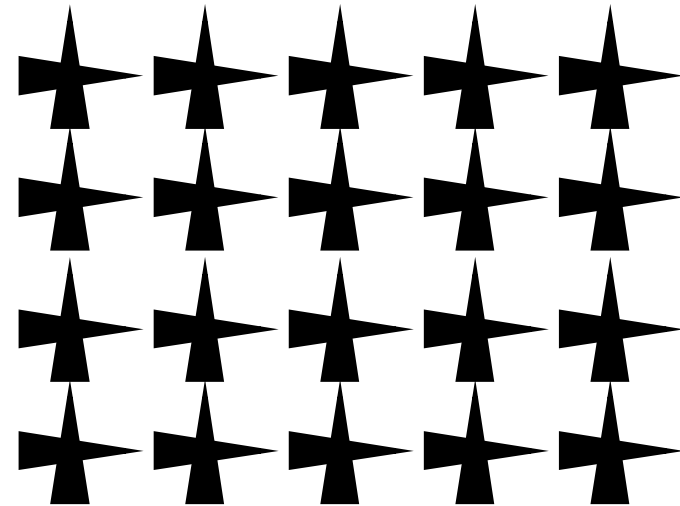
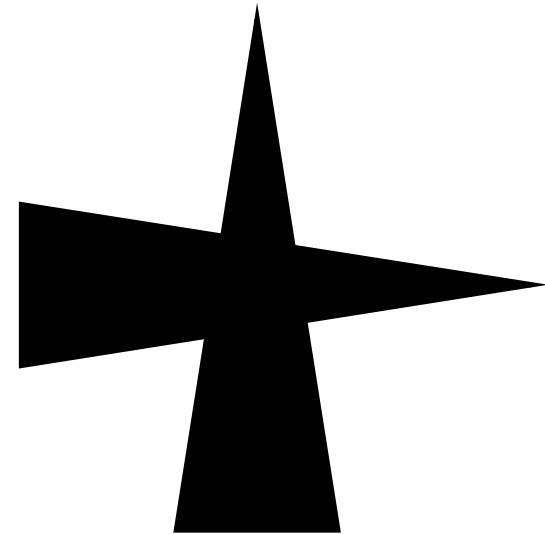
Stanford University



Grating Plasmonics



Attwater group



Conclusions

- Nanotechnology and photonics increasingly important to PV
- Challenges are
 - “self-organised” fabrication
 - integration into fabrication sequence
 - reliability reproducibility of nano processes

